

次世代観測装置用の新しい 回折格子の開発状況 II

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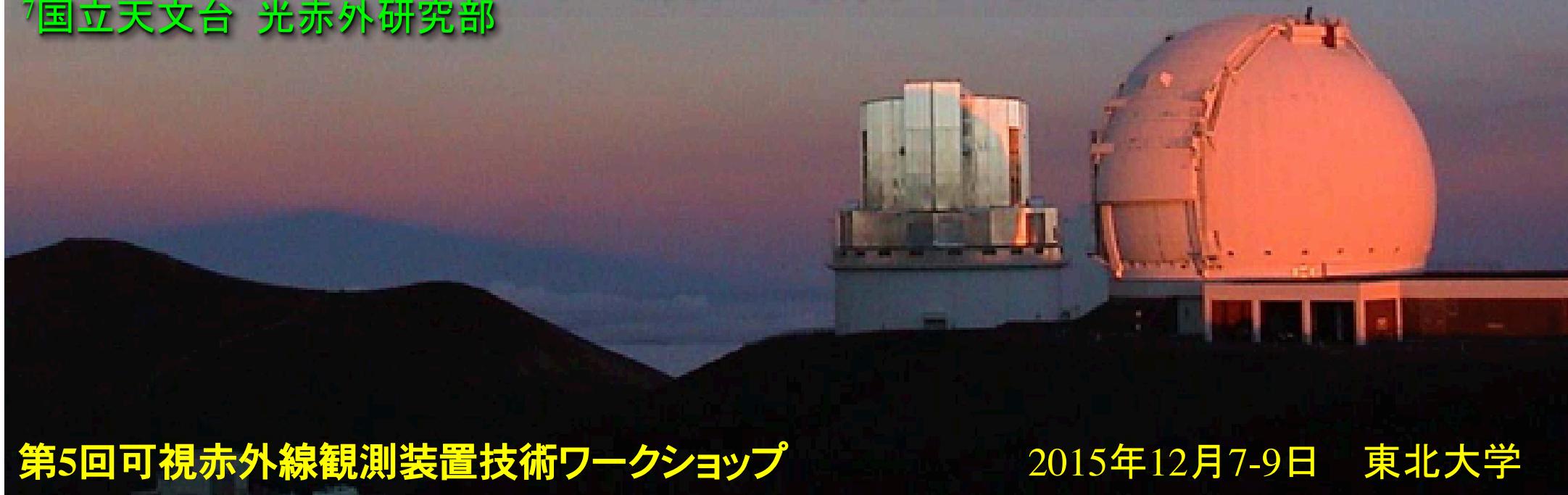
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⁶(株)クリスタル光学 開発部,



Spectrograph of 30m Telescope ($R \sim 50,000 @ 1 \mu\text{m}$)

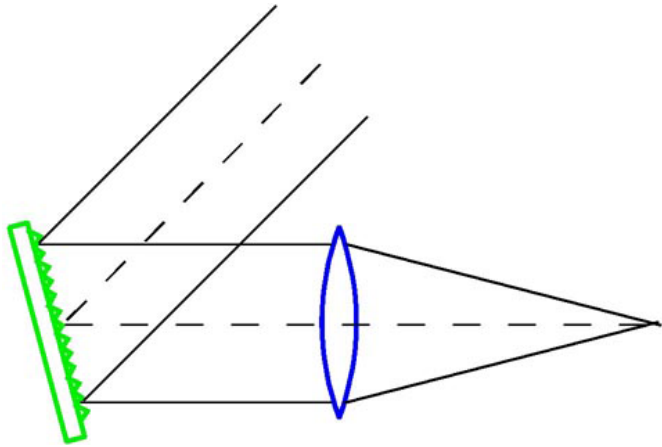
| | Natural seeing: 0.5" | Diffraction limit: 0.0084" | Remarks |
|-------------------------------|----------------------|----------------------------|--|
| Slit width | 727 μm | 12.2 μm | F/10 |
| Dcol | 3 m | 0.05 m | $\alpha = 26.7^\circ$, $\sim 900\text{g/mm}$ |
| Fcol | 30 m | 0.5 m | F/10 |
| Size of spectrograph | 36 × 9 × 4.5 [m] | 0.6 × 0.15 × 0.075 [m] | Littrow mount |
| Camera F | F/0.62 | F/37 | 15 μm × 3 pix. |
| Precision of optical elements | $\sim 3\lambda$ | $< \lambda/20$ | r.m.s. |

A high dispersion grating is necessary!

Novel Gratings under Development

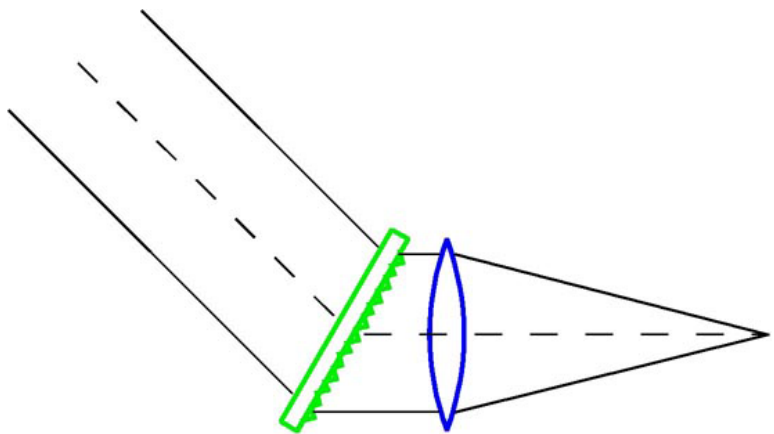
- **Volume phase holographic (VPH) grating** (All most finished for SUBARU)
Thick grating of sinusoidal index modulation for the 1st order diffraction.
- **Birefringence VPH grating**
VPH grating of which spectral efficiency is coincide with S and P polarization by using birefringent media.
- **Birefringence Bragg binary (3B) grating**
Thick rectangular grating of which spectral efficiency is coincide with S and P polarization by using birefringent media. Available for the 1st and several diffraction order.
- **Surface relief grating with acute angle grooves**
Replicated grism for MOIRCS with high index prism. (3rd ~6th diffraction order).
- **Quasi-Bragg grating**
Transmission grating for high diffraction order fabricated by lamination of mirror plates. Having the imaging capability.
- **Immersion grating** (Already developed in 10 μ m band, under development for the near-infrared)
High dispersion echelle grating of which optical path is filled up a high index media.
- **Quasi-Bragg immersion grating**

Reflection and Transmission Grating



Reflection grating

- Utilize wide range electromagnetic wave from X ray to THz.
- Relatively inexpensive.

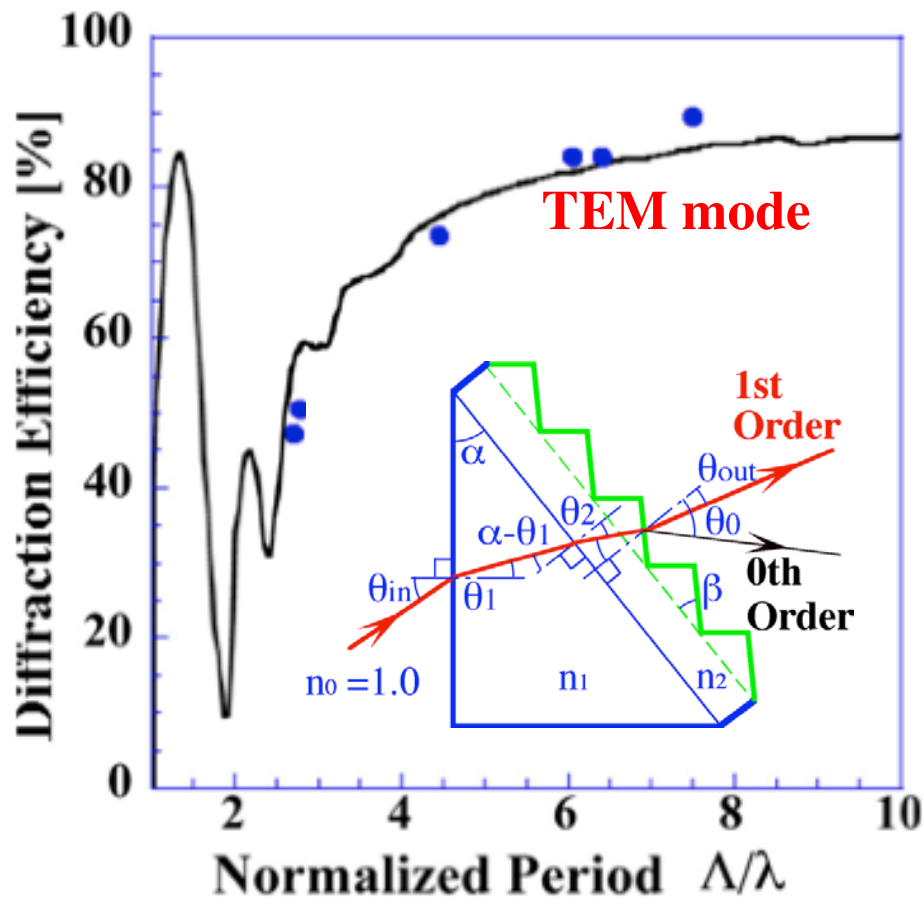


Transmission grating

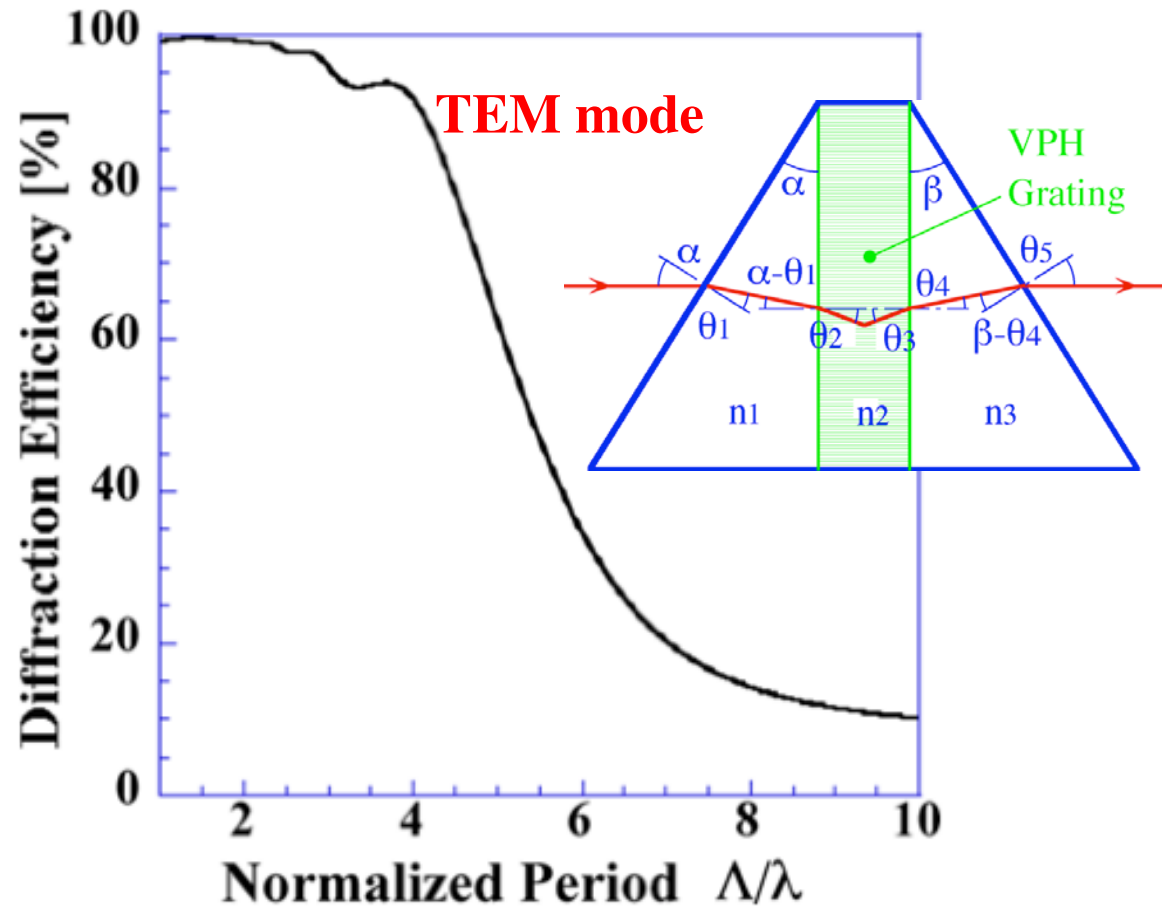
- Collimator and camera optics could place nearby the grating.
- It is able to reduce size of the spectrometer.

Development of the transmission grating for higher-order diffraction with high dispersion has been demanded.

Efficiencies of Transmission Gratings

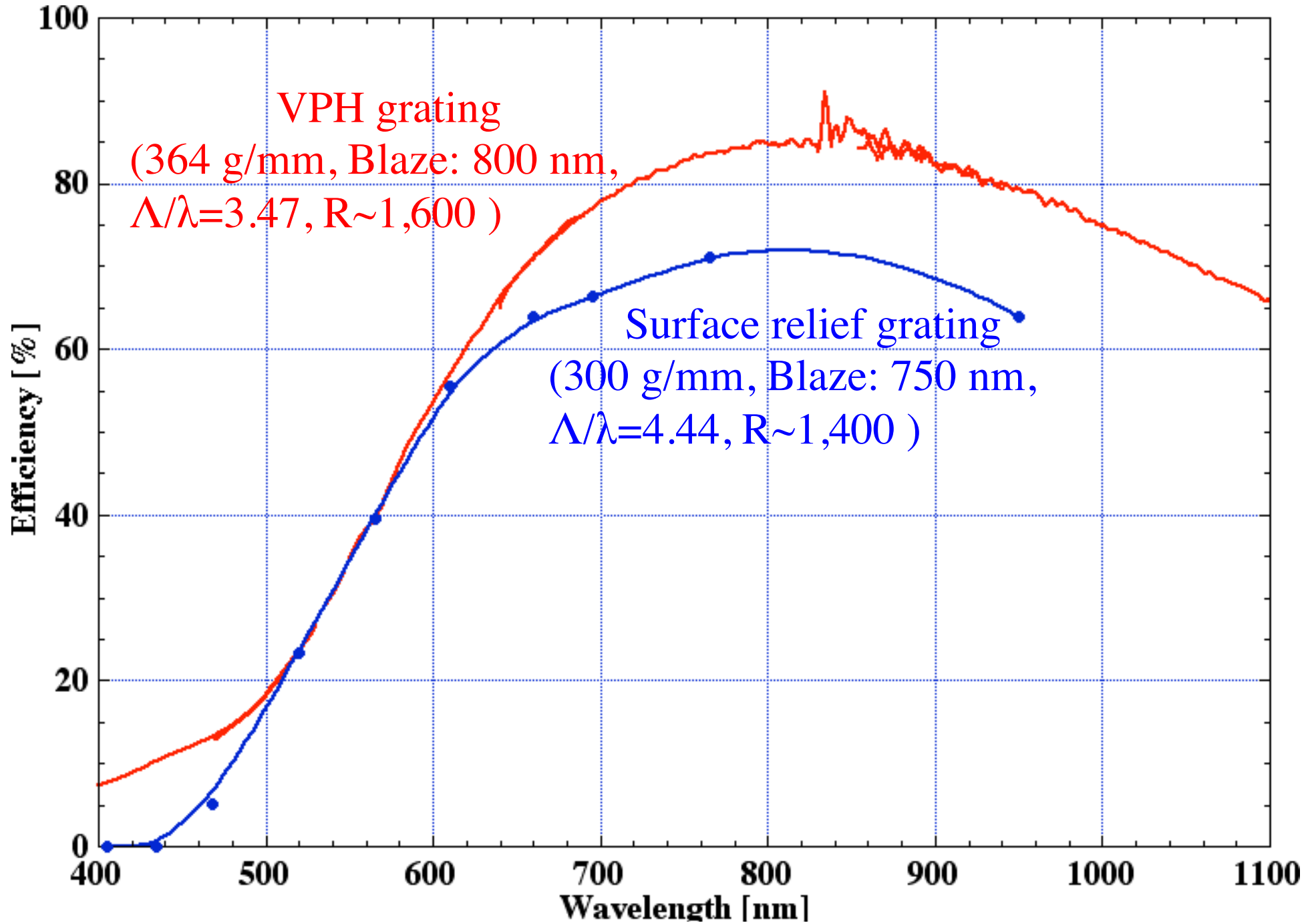


Surface relief grating:
Efficiency decreases
steeply below $4 \Lambda/\lambda$



VPH (Volume Phase Holographic)
grating ($\Delta n \sim 0.02$): Efficiency
increases up to 100% below $4 \Lambda/\lambda$.

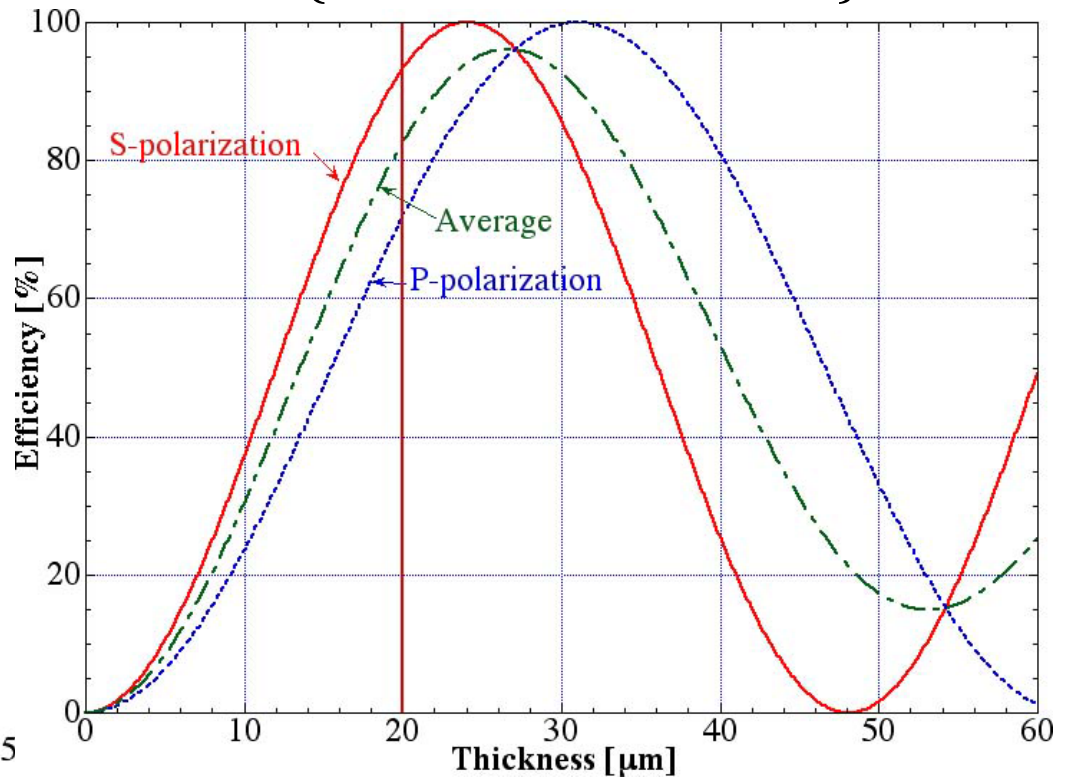
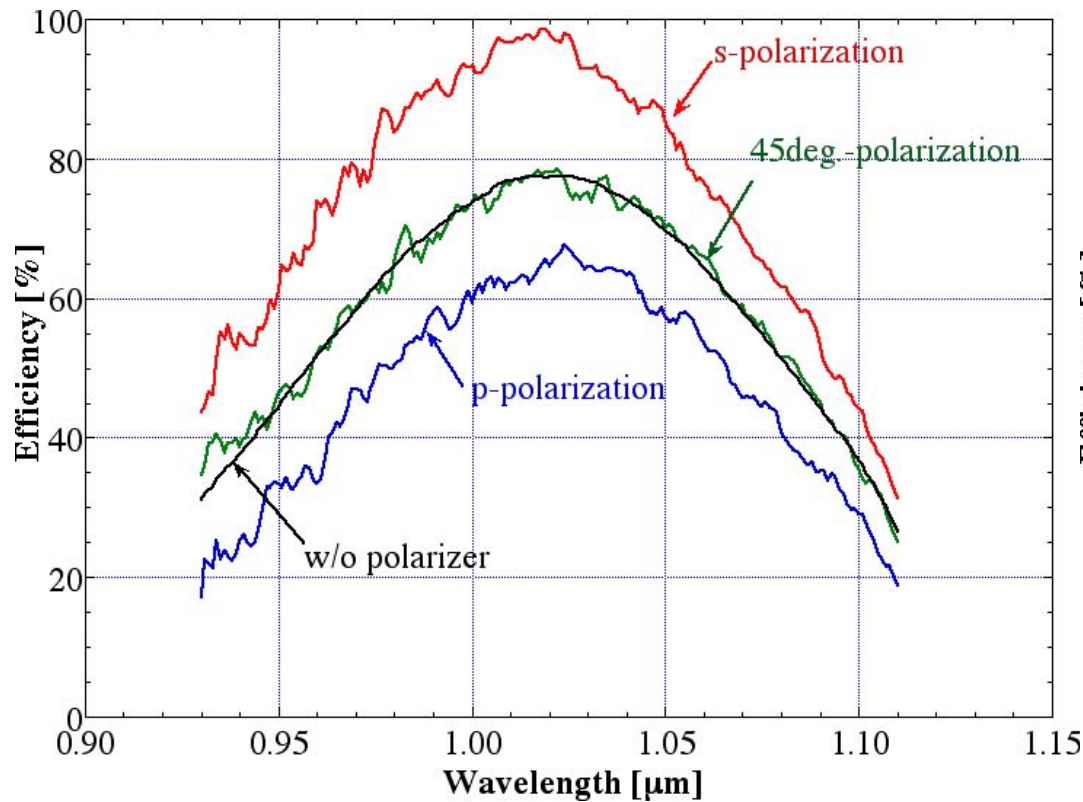
Diffraction Efficiencies of VPH Grism for FOCAS



Polarized Diffraction Efficiency of VPH Grating

$$\eta_S = \sin^2 \left\{ \frac{\pi(n_{\max} - n_{\min})t}{\Lambda(n_{\max} + n_{\min})\sin 2\theta} \right\}$$

$$\eta_P = \sin^2 \left\{ \frac{\pi(n_{\max} - n_{\min})t \cos 2\theta}{\Lambda(n_{\max} + n_{\min})\sin 2\theta} \right\}$$



Measured polarized diffraction efficiencies of a prototype VPH grating for a MOIRCS grism.
 $n_{\text{ave}}=1.53$, $\Lambda=0.984 \mu\text{m}$ $t = 20 \mu\text{m}$,
 $\theta=19.8^\circ @ \lambda=1.02 \mu\text{m}$.

Calculated polarization diffraction efficiencies versus thickness of a VPH grating with refractive index modulation: $\Delta n=0.017$.

[Ebizuka et al., PASJ, **63**, 2011b]

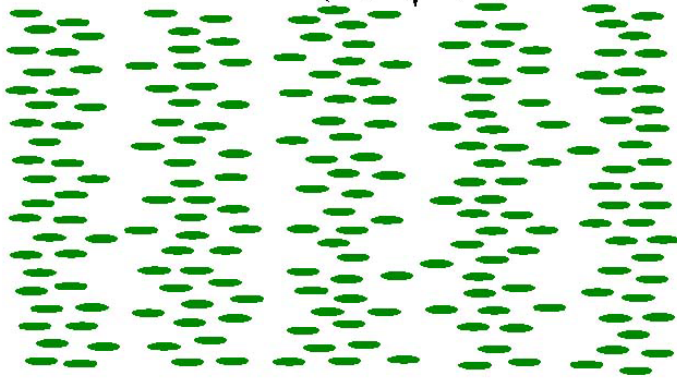
Birefringence VPH Grating

Amplitude of two beams

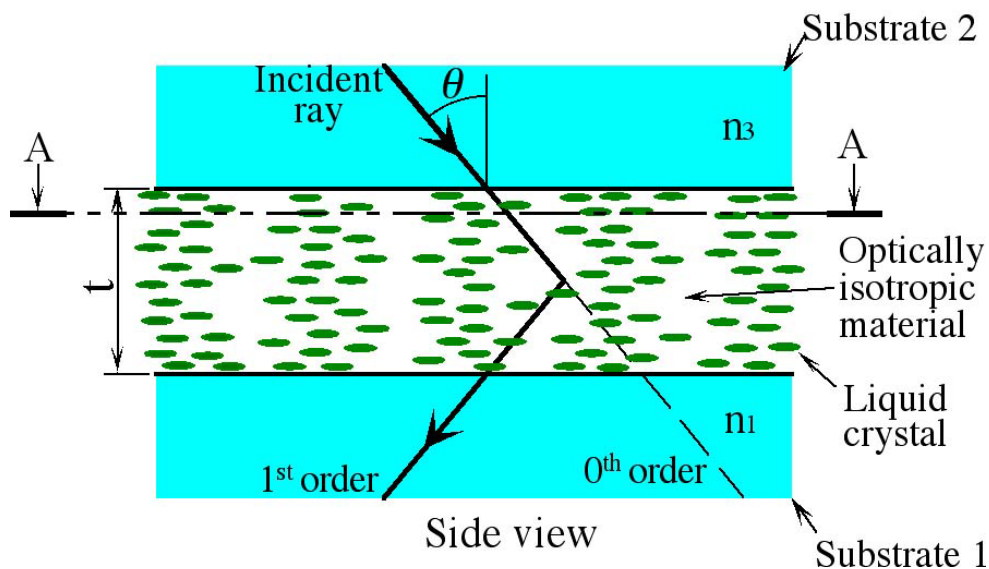


Retardation $\delta = 0 \quad \pi/2 \quad \pi \quad 3\pi/2 \quad 2\pi$

Amplitude of interferogram



Λ Cross section: A-A

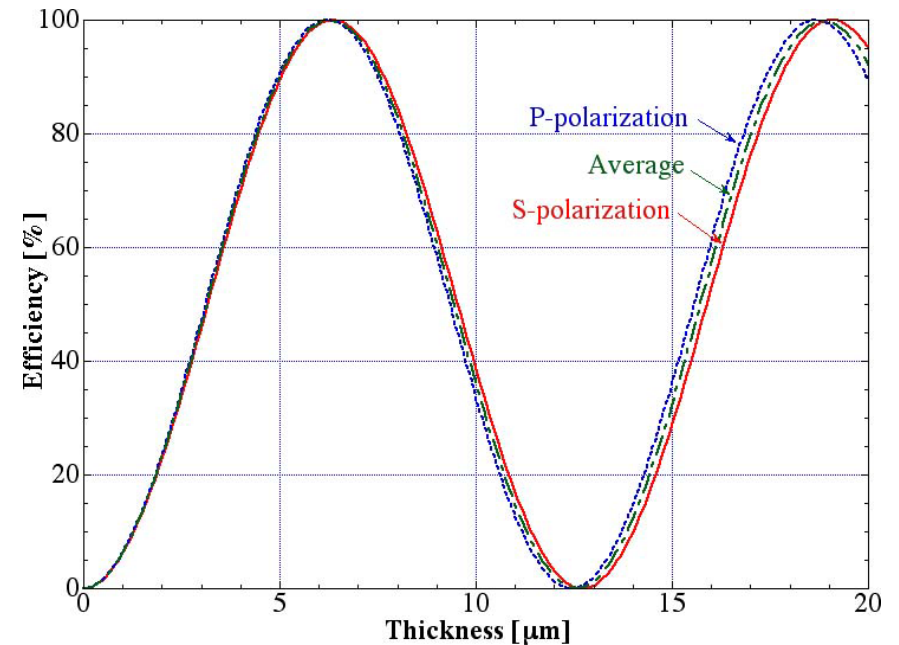


$$\frac{n_{S_{\max}} - n_{S_{\min}}}{(n_{S_{\max}} + n_{S_{\min}})\sin 2\theta_S} = \frac{(n_{P_{\max}} - n_{P_{\min}})\cos 2\theta_P}{(n_{P_{\max}} + n_{P_{\min}})\sin 2\theta_P}$$

$$\frac{n_{S_{\max}} - n_{S_{\min}}}{(n_{S_{\max}} + n_{S_{\min}}) \cdot 2\sin\theta_S} \cos\theta_S = \frac{(n_{P_{\max}} - n_{P_{\min}})\cos 2\theta_P}{(n_{P_{\max}} + n_{P_{\min}}) \cdot 2\sin\theta_P} \cos\theta_P$$

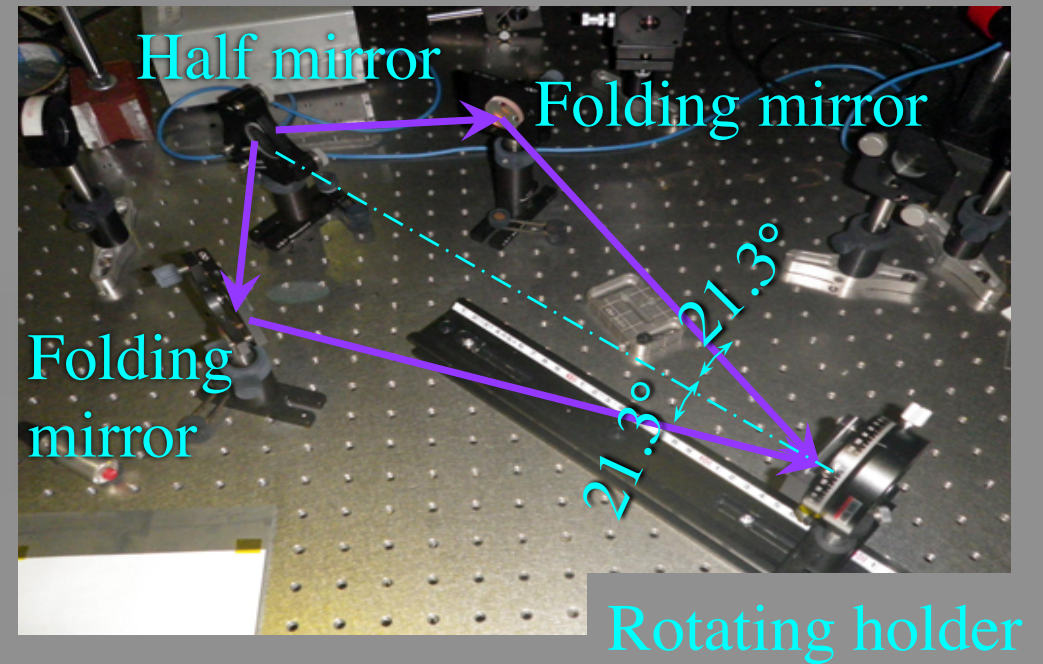
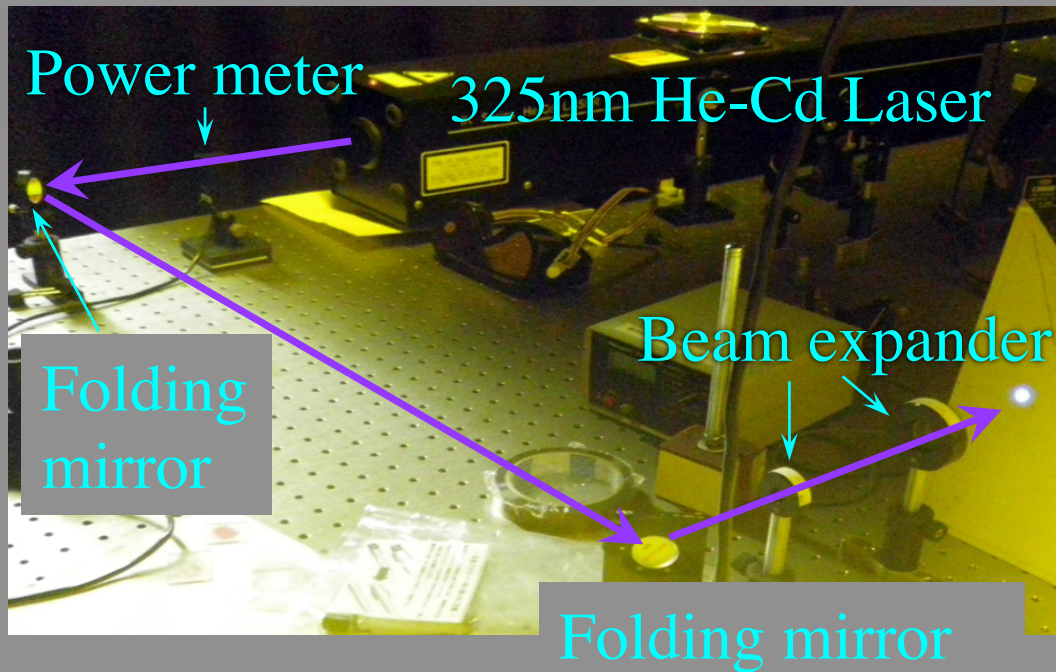
Snell's law

$$\frac{n_{S_{\max}} - n_{S_{\min}}}{\cos\theta_S} \cong \frac{(n_{P_{\max}} - n_{P_{\min}})\cos 2\theta_P}{\cos\theta_P}$$



Calculated polarization diffraction efficiencies versus grating thickness t of birefringence VPH grating.

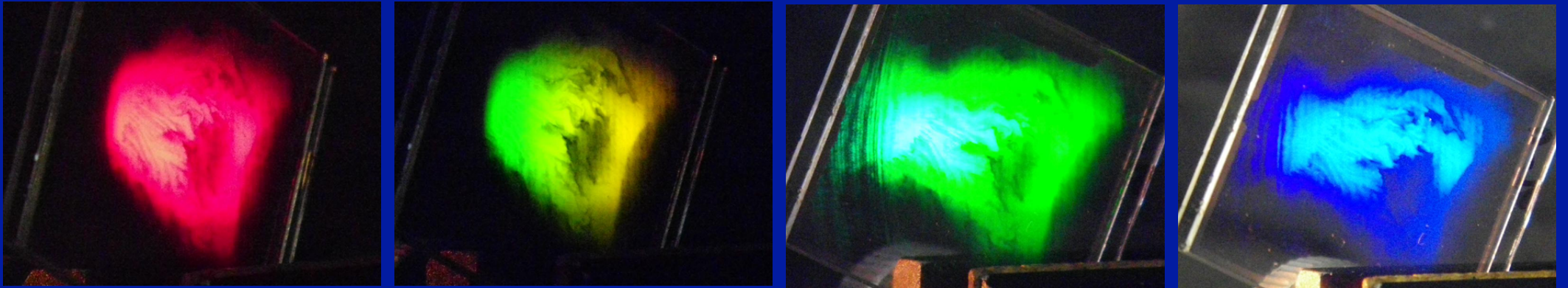
Fabrication for Liquid Crystal Grating



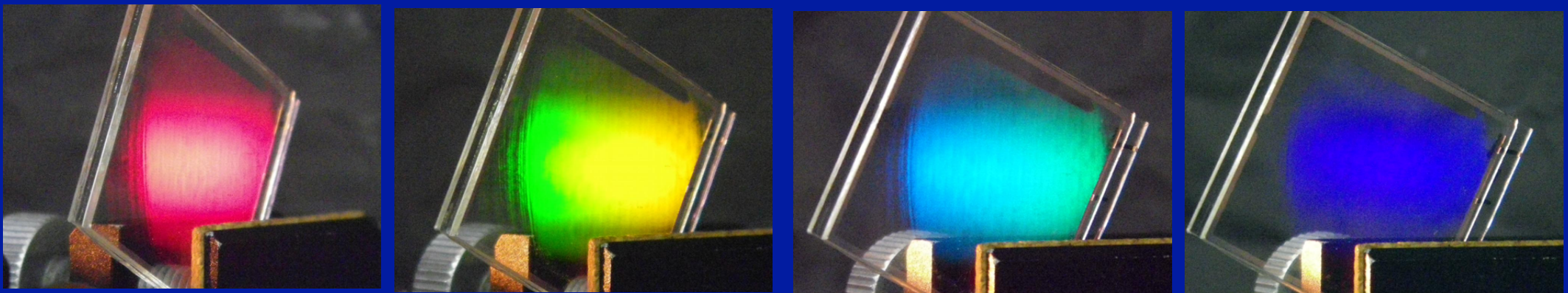
Two beam interference exposure optics

$$\Lambda = m\lambda / 2\sin\theta_B = 0.325 / 2\sin 21.3^\circ = 0.447 \text{ [\mu m]} \\ (2,235 \text{ grooves/mm})$$

Liquid Crystal VPH grating

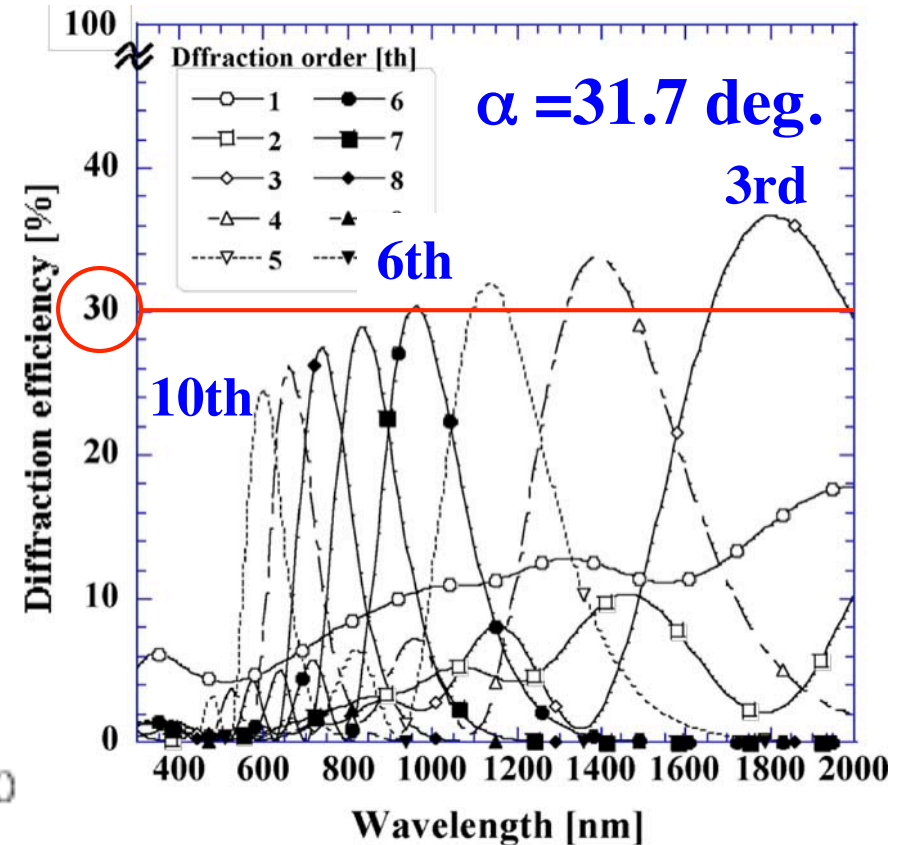
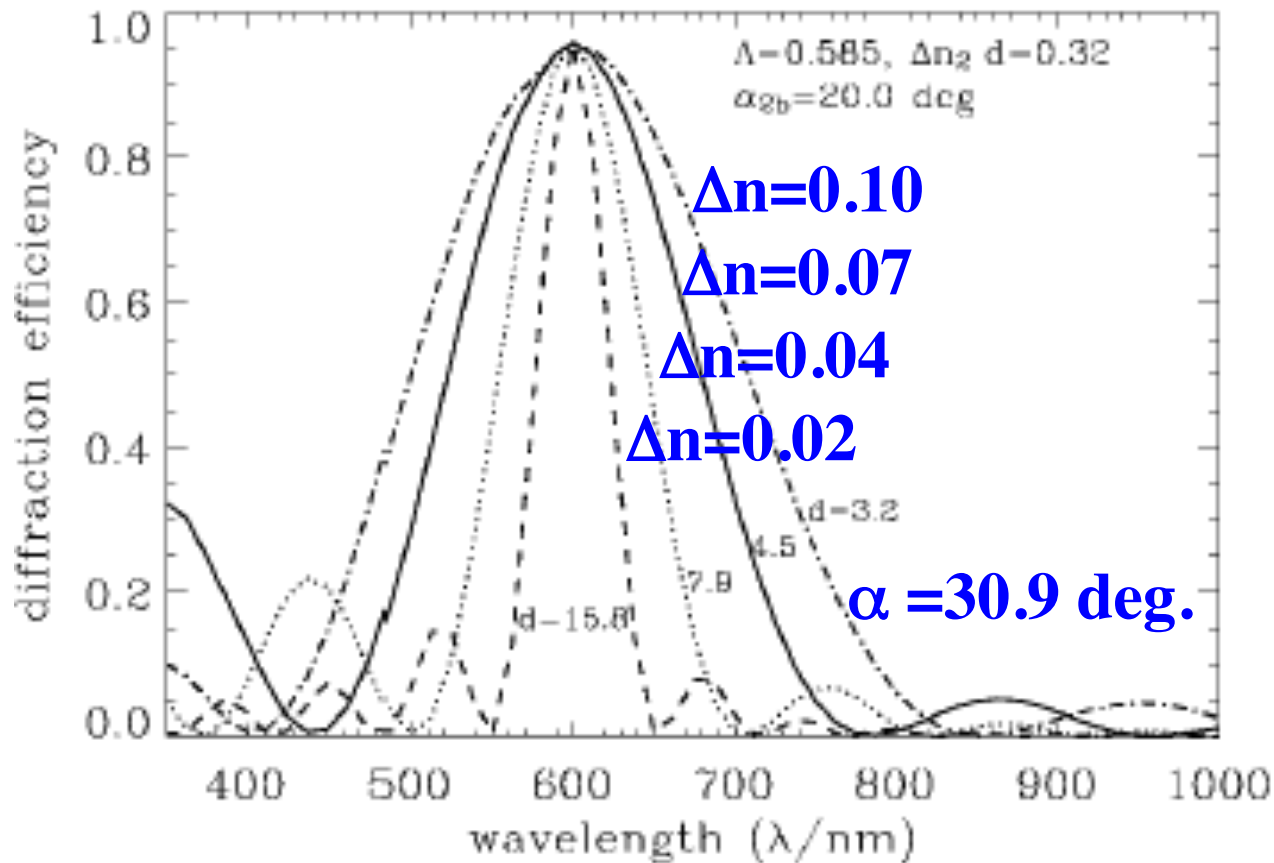


DIC ULC17A+Merck MJ041609, UV: 11mW, 180sec.



DIC TKN+Merck MJ041609, UV: 12.4 mW, 180sec.

Limitation of VPH Grating



Band width of VPH grating becomes narrow in diffraction angle: α increase because semi-amplitude of index modulation (Δn) of dichromated gelatin (DCG) is up to 0.15.

[Baldry et al., PASP, 116, 2004]

Diffraction efficiency of VPH grating decrease toward higher orders.

[Oka et. al., SPIE, 5290, 2004]

MOIRCS SR Grism

Prism material 1 : ZnSe ($n_1 = 2.4529 @ 1.65 \mu\text{m}$)

Plate : S-FPM3 ($n_2 = 1.5240 @ 1.65 \mu\text{m}$)

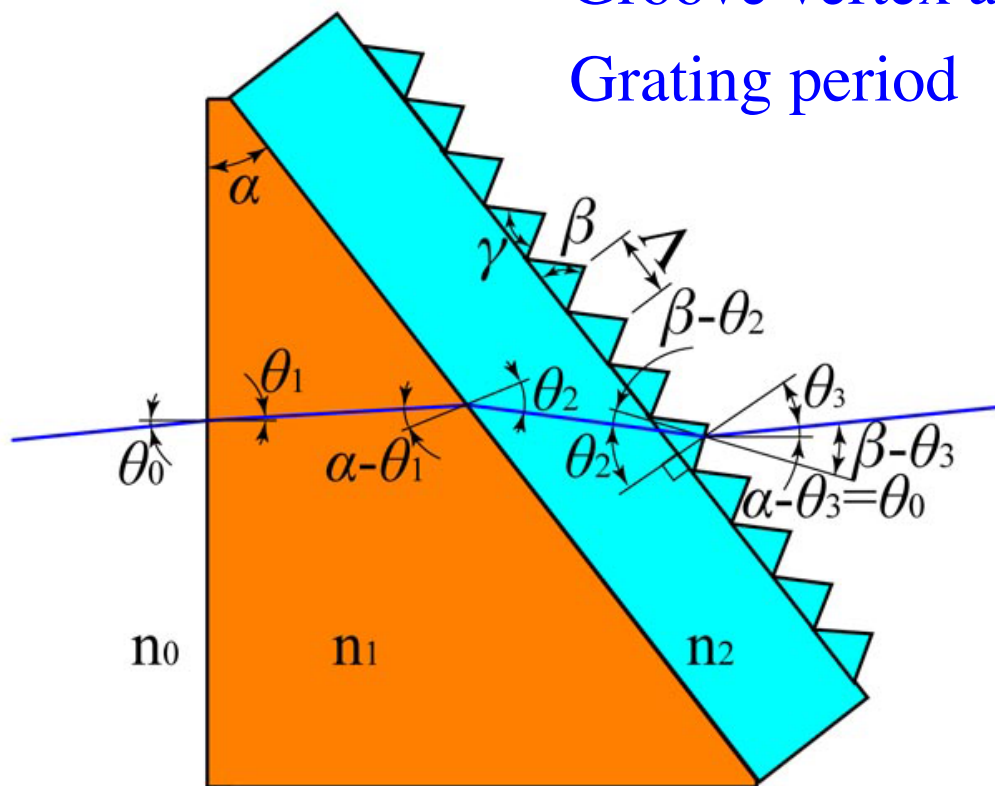
Prism vertex angle : $\alpha = 23.8^\circ$

Incident angle : $\theta_0 = 5^\circ$

Groove blaze angle : $\beta = 64.8^\circ$

Groove vertex angle : $\gamma = 61.8^\circ$

Grating period : $\Lambda = 10.79 \mu\text{m}$ (92.68 grooves/mm)



7th, R= 1,487 @ 0.88 μm (z band)

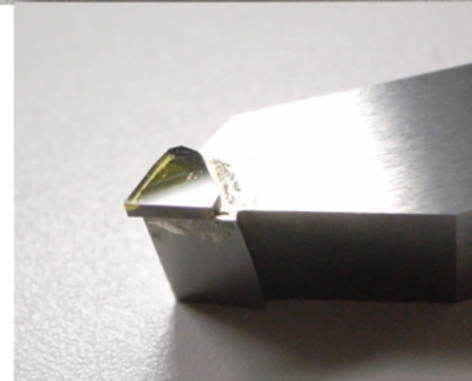
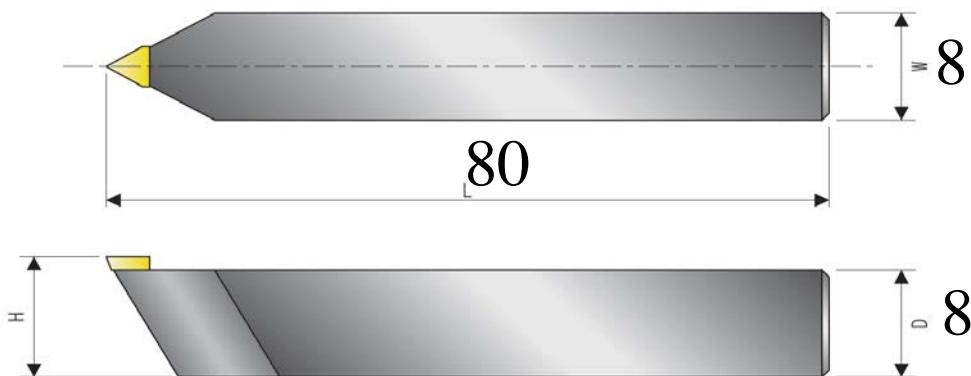
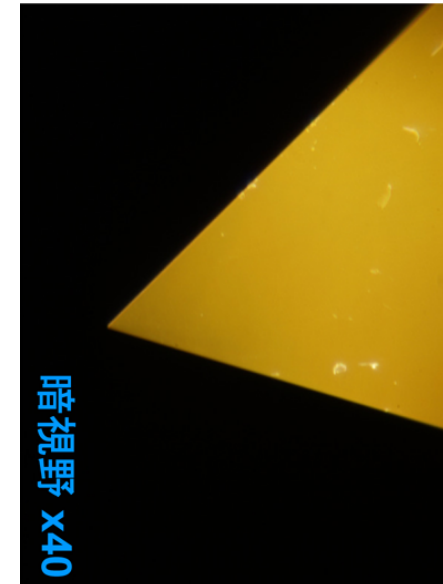
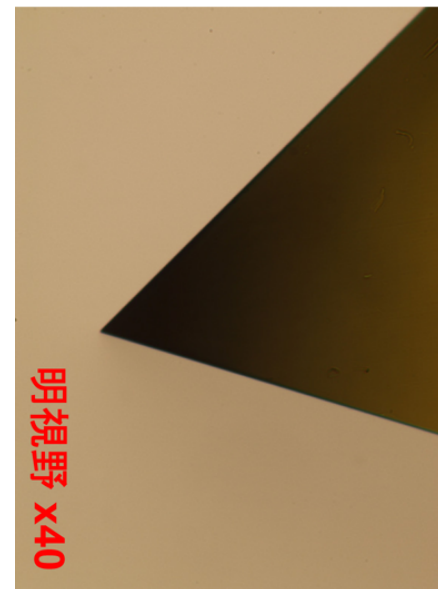
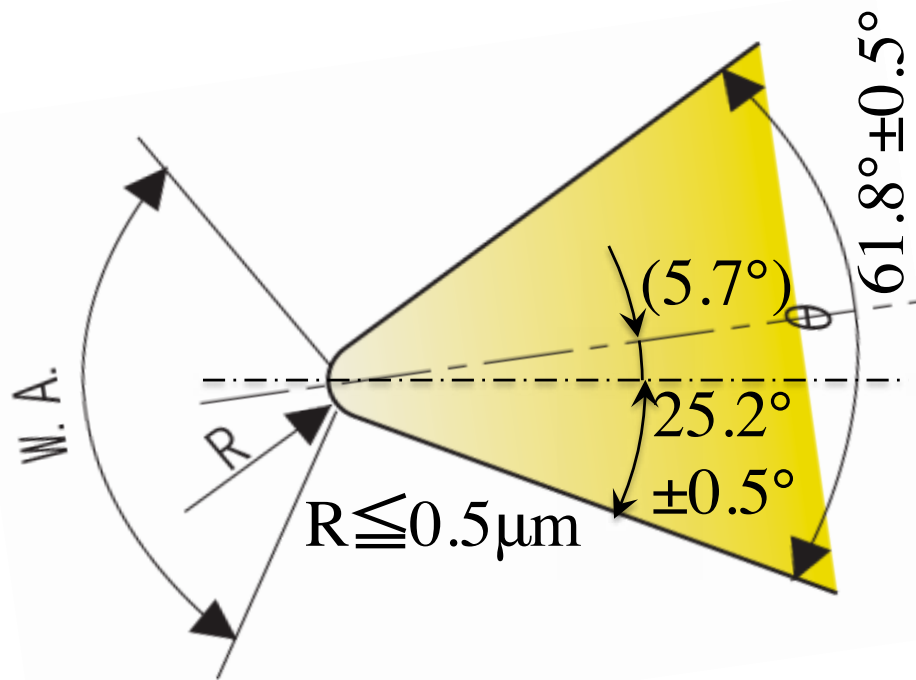
6th, R= 1,431 @ 1.02 μm (Y band)

5th, R= 1,408 @ 1.25 μm (J band)

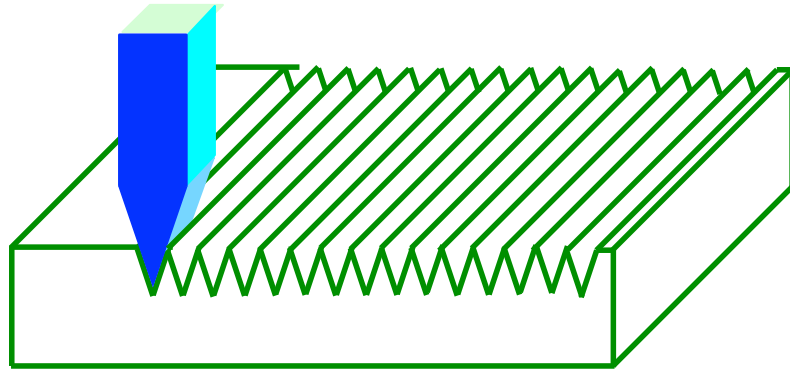
4th, R= 1,434 @ 1.65 μm (H band)

3rd, R= 1,419 @ 2.20 μm (K band)

Diamond Bite for Master Grating



Fabrication Method for MOIRCS SR Grating



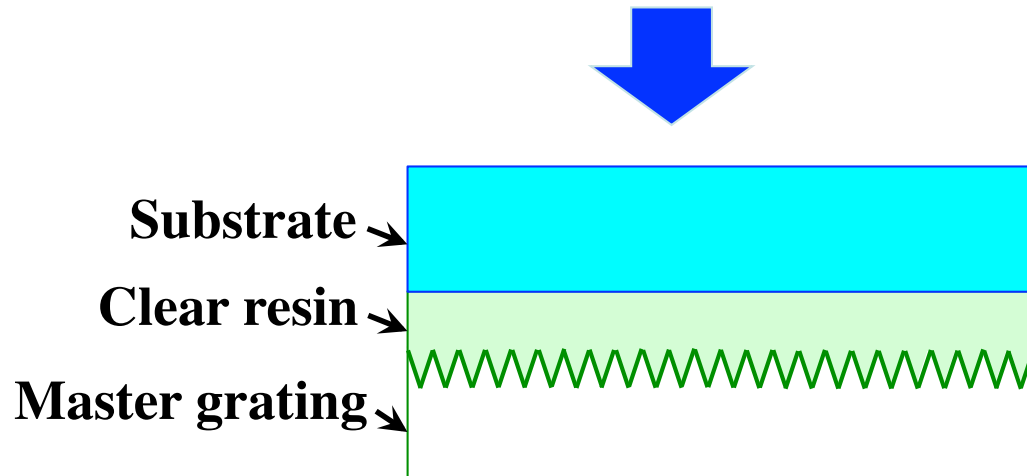
Shaper cutting of master grating

Work : Ni-P alloy of Non-electrolytic plating

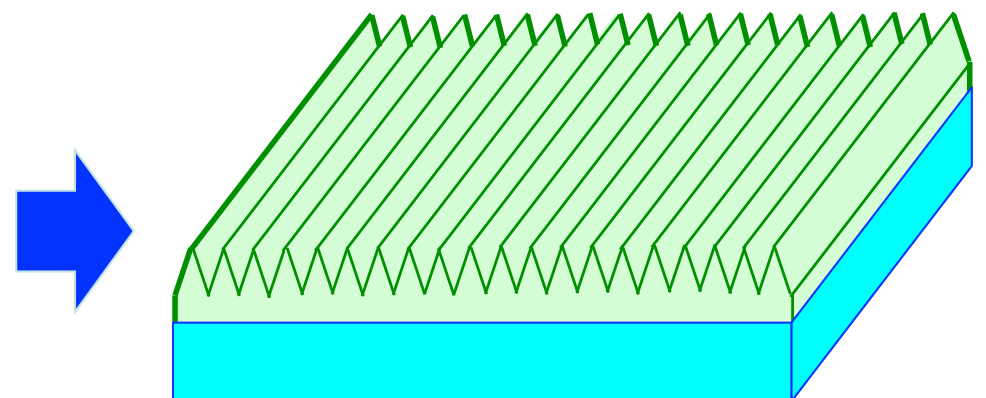
Blaze angle : $\beta = 64.8^\circ$

Vertex angle : $\gamma = 61.8^\circ$

Grating period : $\Lambda = 10.79\mu\text{m}$



Replication



Finish

Limitation of Surface Relief Grating

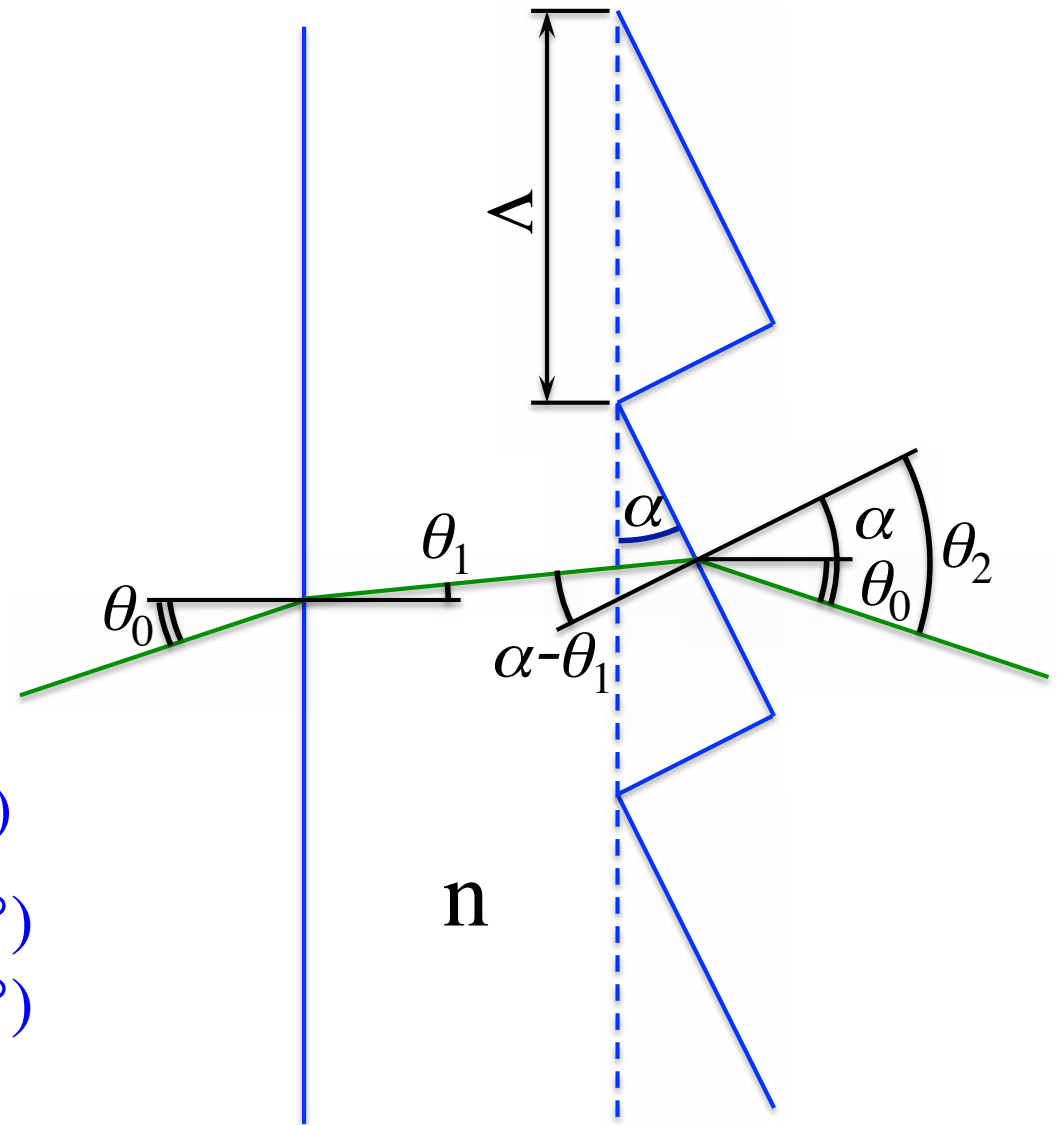
$$\begin{aligned}\sin\theta_0 &= n \sin\theta_1 \\ n \sin(\alpha - \theta_1) &= \sin\theta_2 \\ \theta_2 &= \alpha + \theta_0\end{aligned}$$

$$\begin{aligned}n \sin(\alpha - \theta_1) &= \sin(\alpha + \theta_0) \\ n (\sin\alpha \cos\theta_1 - \sin\theta_1 \cos\alpha) &= \sin\alpha \cos\theta_0 + \sin\theta_0 \cos\alpha \\ (n \cos\theta_1 - \cos\theta_0) \sin\alpha &= (\sin\theta_0 + n \sin\theta_1) \cos\alpha \\ \tan\alpha &= 2\sin\theta_0 / (n \cos\theta_1 - \cos\theta_0)\end{aligned}$$

$$n = 1.8, \theta_0 \leq 36^\circ (\theta_2 > 90^\circ)$$

$$n = 3.0, \theta_0 \leq 54^\circ (\theta_2 > 90^\circ)$$

Diamond: $n = 2.46@400\text{nm}$

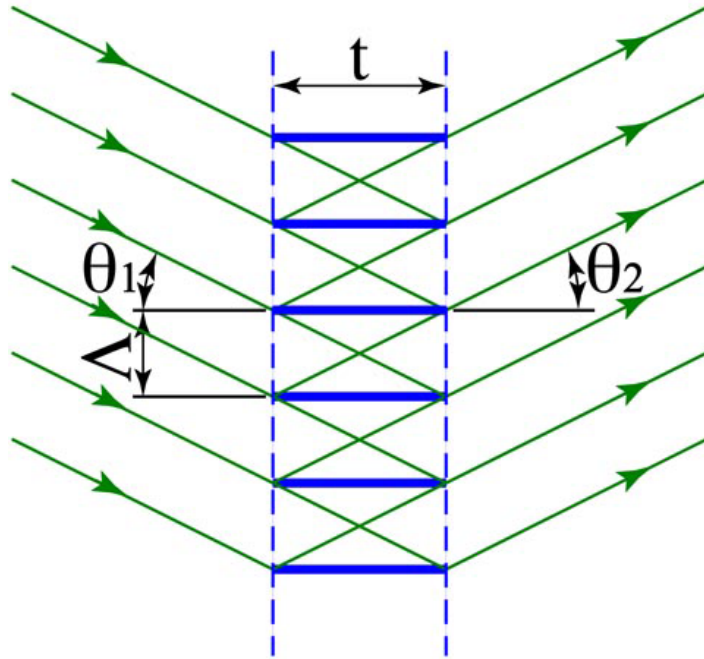


Surface relief grating with saw tooth grooves is not feasible for the medium and high res. gratings.

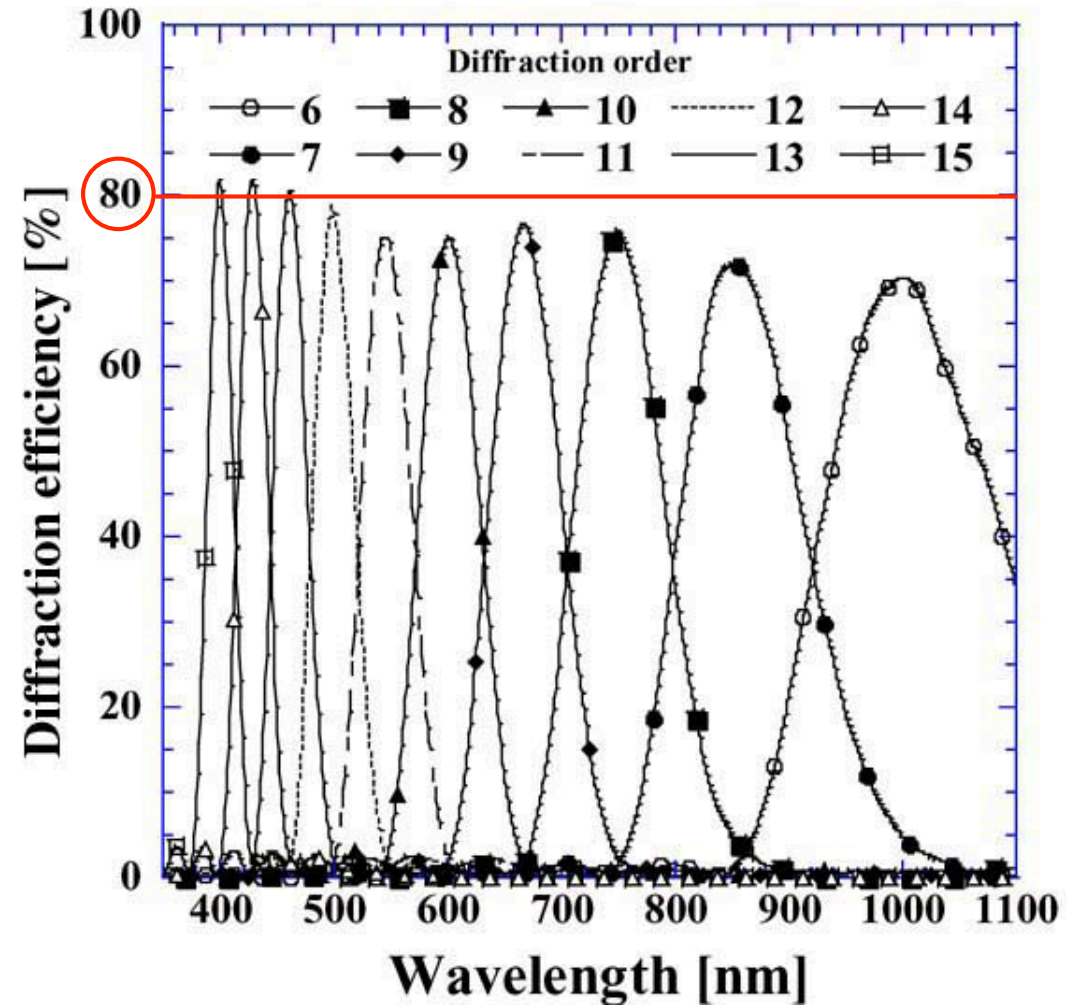
Quasi-Bragg grating



Quasi-Bragg Grating for Higher Orders

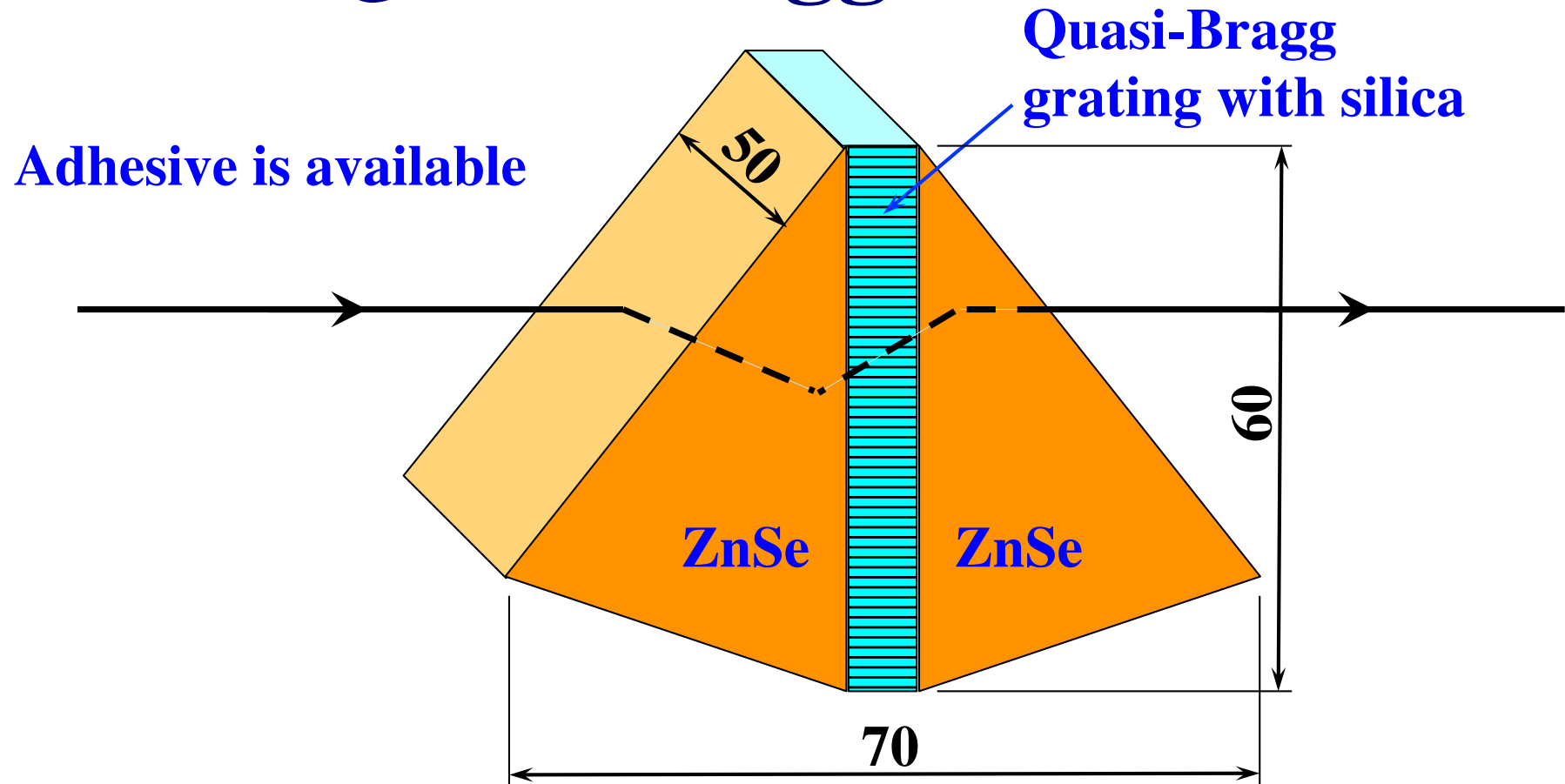


- Quasi-Bragg grating (QBG) achieves high diffraction efficiency toward higher order.
- QBG inherits advantages of VPH grating.
- QBG has the imaging property.



Diffraction Efficiency of quasi-Bragg grating. $n = 1.50$, $\Lambda = 5.71 \mu\text{m}$, $t = 15.27 \mu\text{m}$, $\theta_1 = \theta_2 = 20.51^\circ$.

Quasi-Bragg Grism



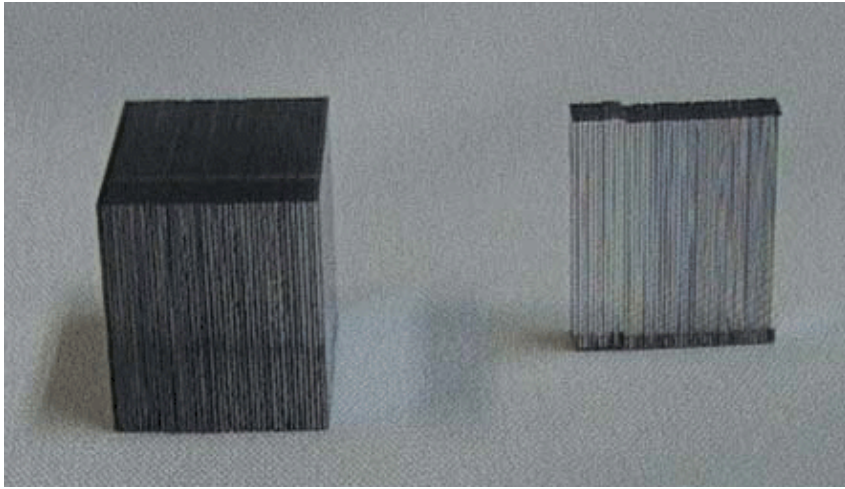
Visible (300~1000nm), Near IR (1.0~2.5 μ m)

Substrate : Silica, optical glass etc.

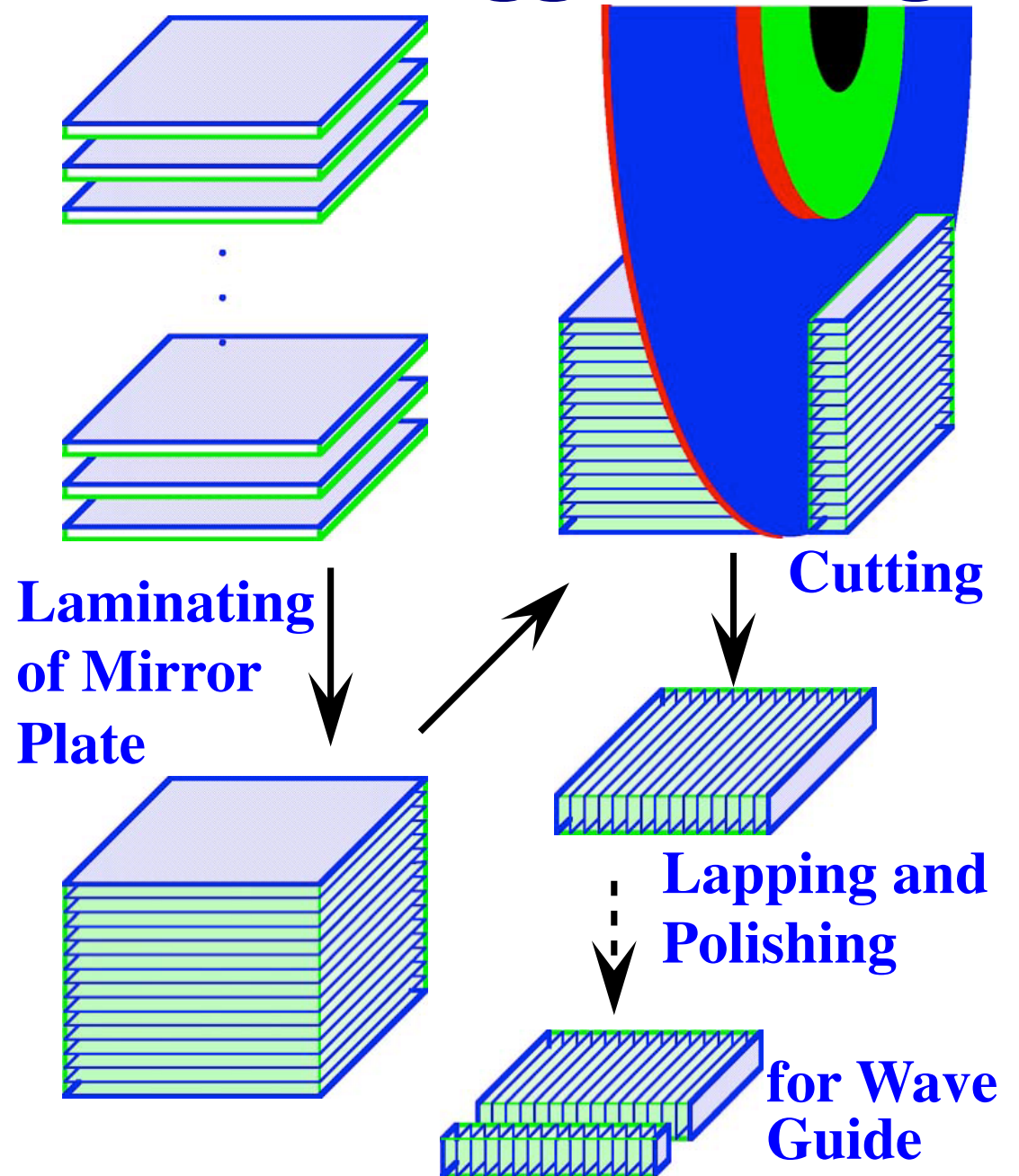
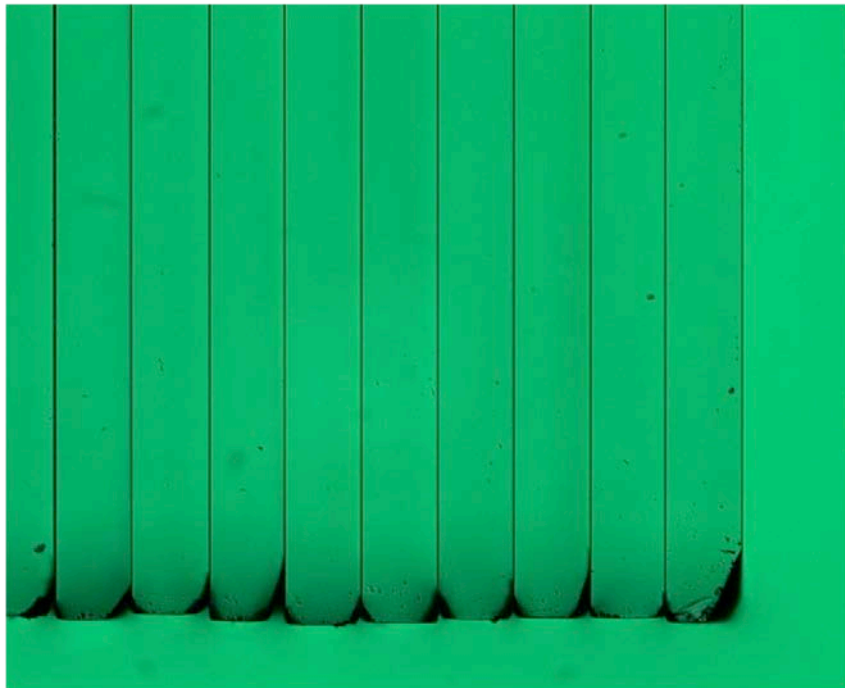
Size \times No. of layer: 50 \times 0.54 \times t0.2 \times 350psc.

Periodic error : 100~500nm (P-V), 20~100nm (rms)

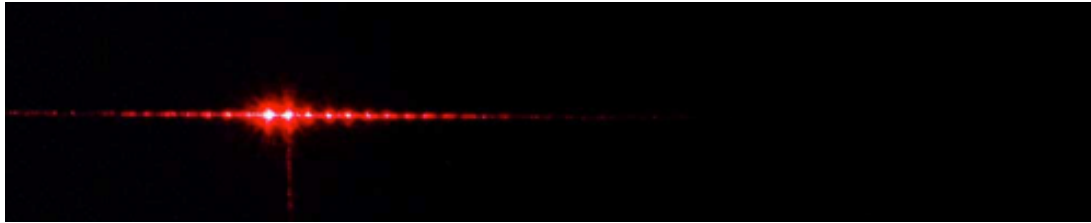
Trial Fabrication of Quasi-Bragg Grating 1



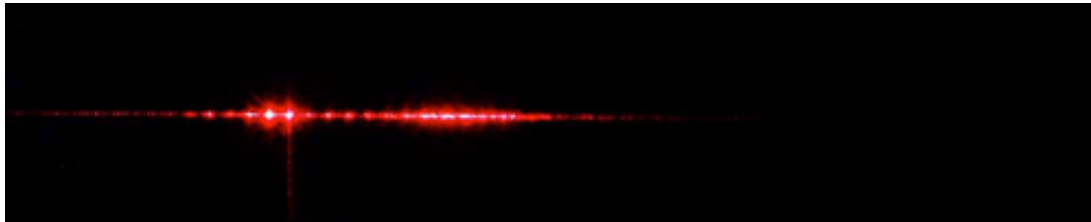
A: 10 x 10 x 0.2 x 40 pcs (left),
B: 1.5 x 10 x 0.2 x 40 pcs (right)



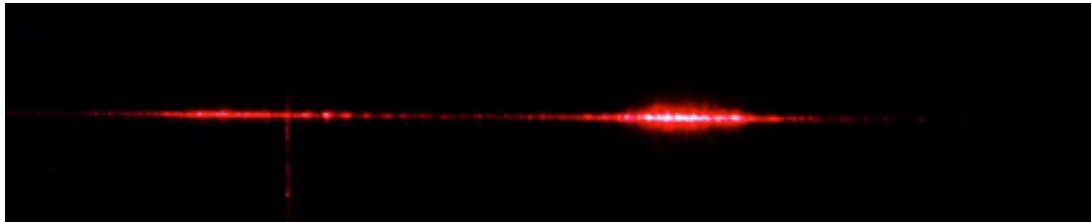
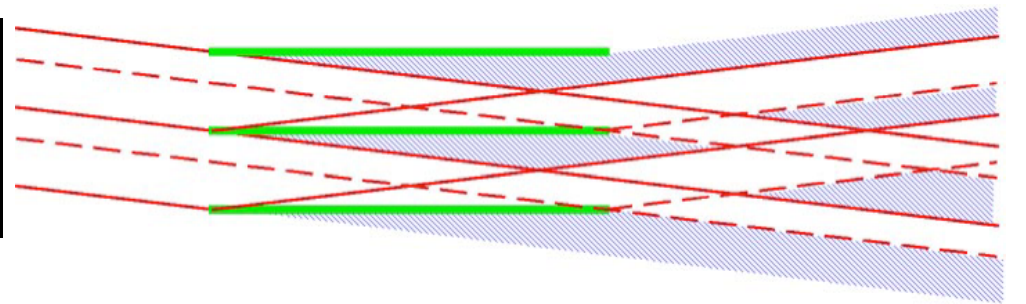
Diffraction by Quasi-Bragg Grating



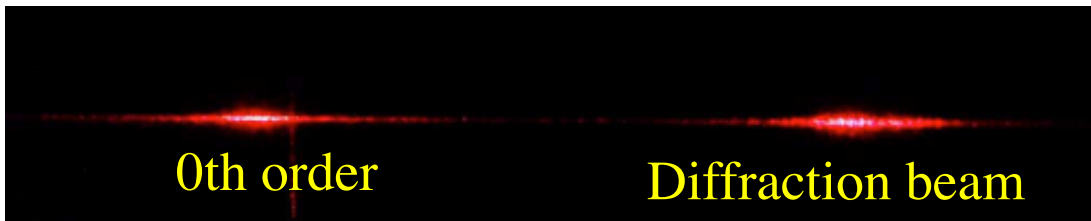
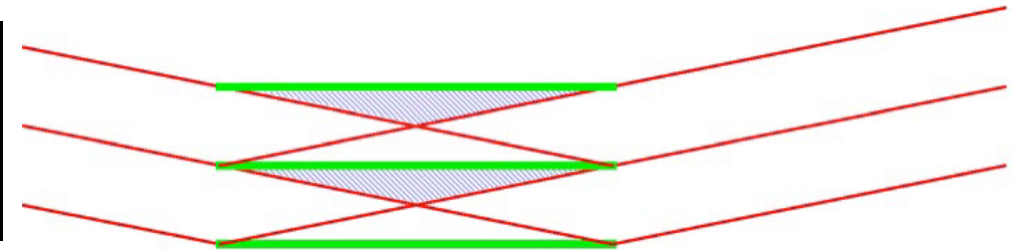
Normal incidence



Small incident angle



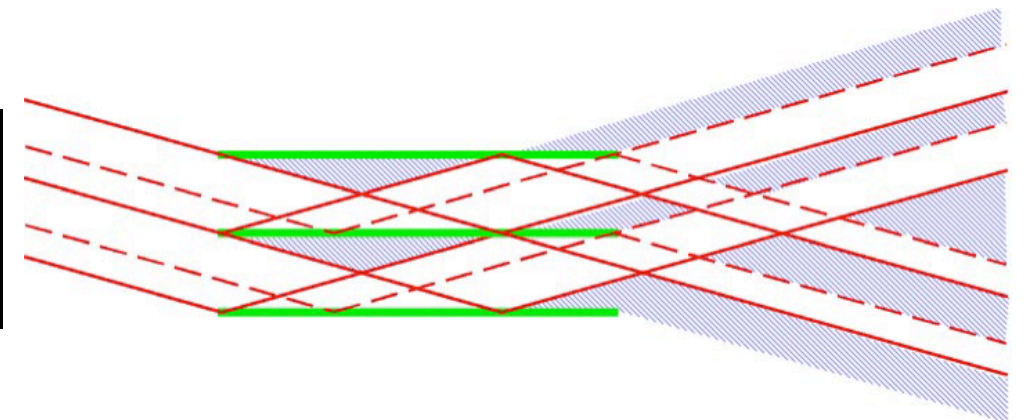
Ideal incident angle



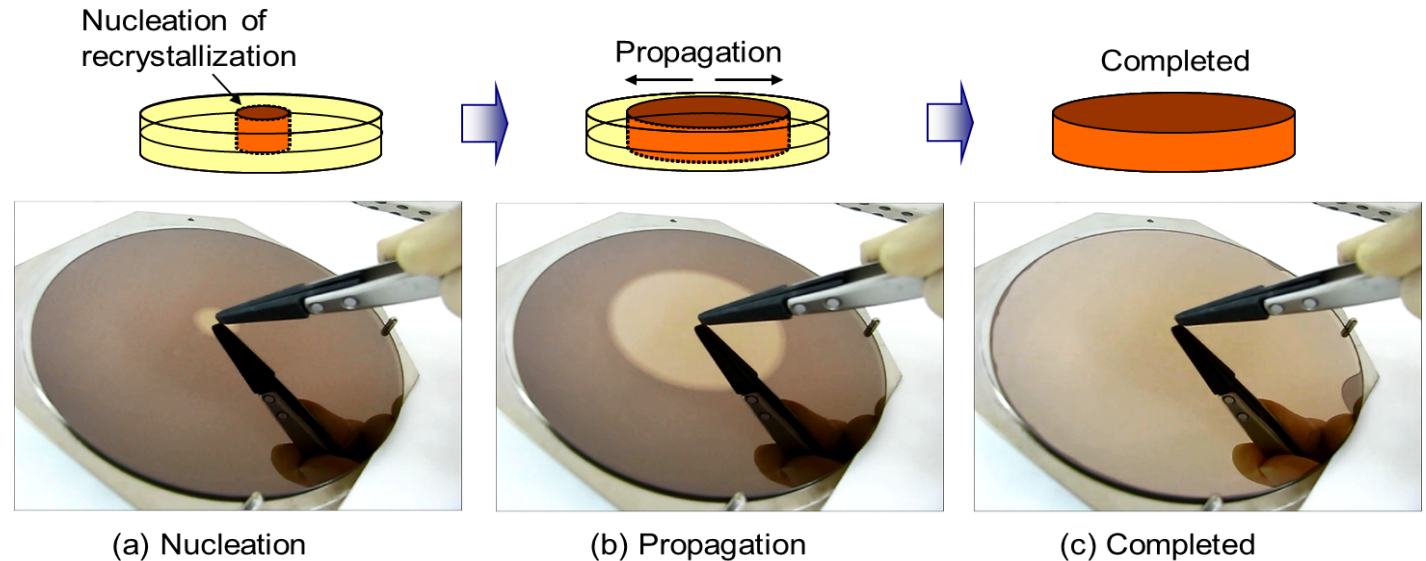
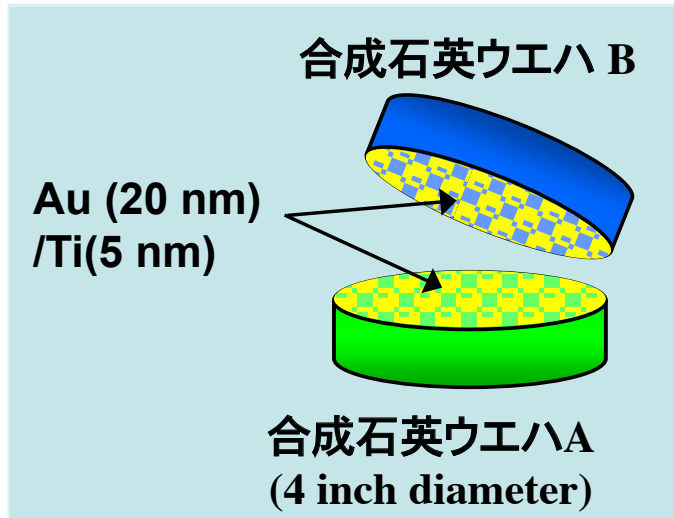
0th order

Diffraction beam

Large incident angle



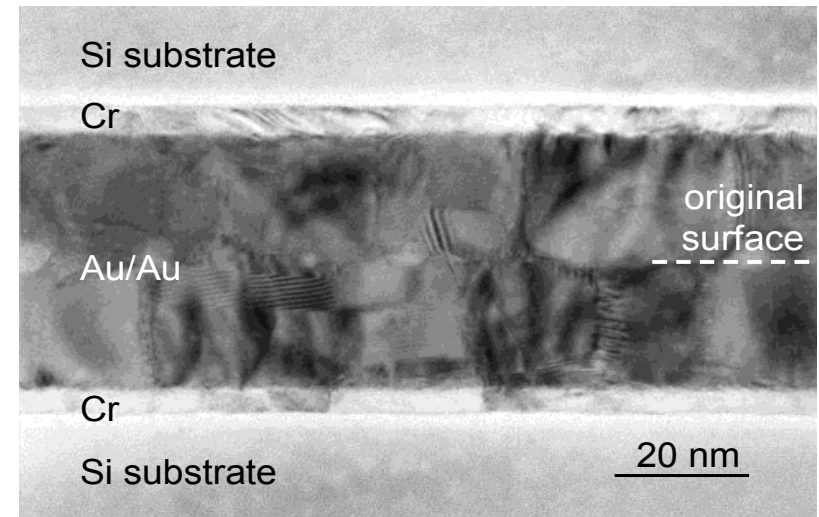
Au膜を用いた大気中の原子拡散接合法



片側あたり Au(20 nm)/Ti(5 nm)の膜厚で合成石英ウエハを接合した際の連続写真

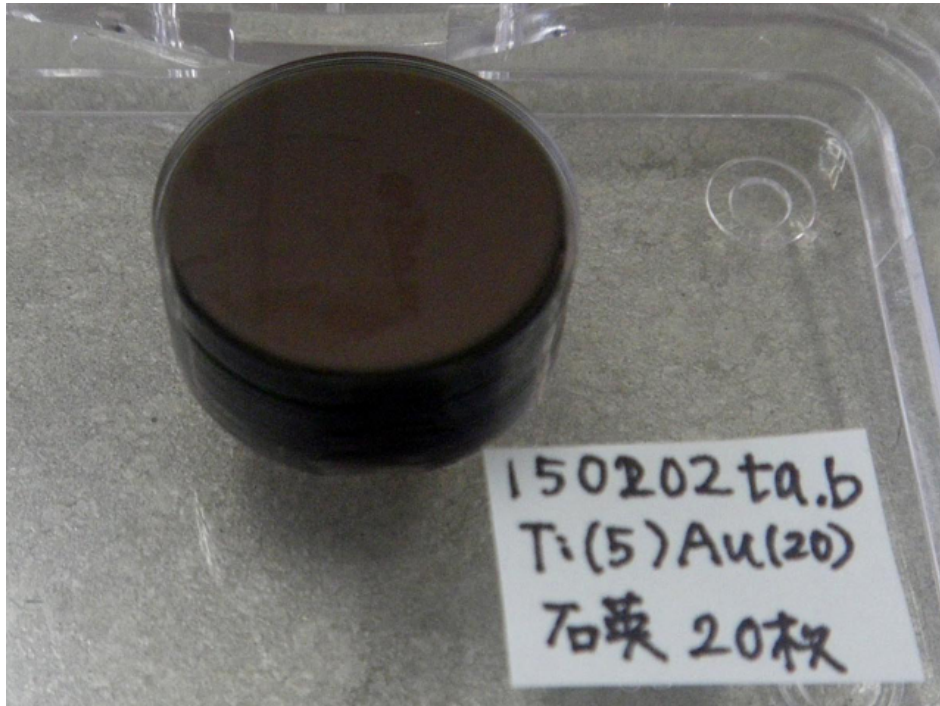
◆ 重ねたウエハの一部をピンセット等で加圧すると、**Au/Au界面に再結晶の核が形成され、瞬時にウエハ全体に伝搬。**

◆ 真空中の接合でも同様であると推定。

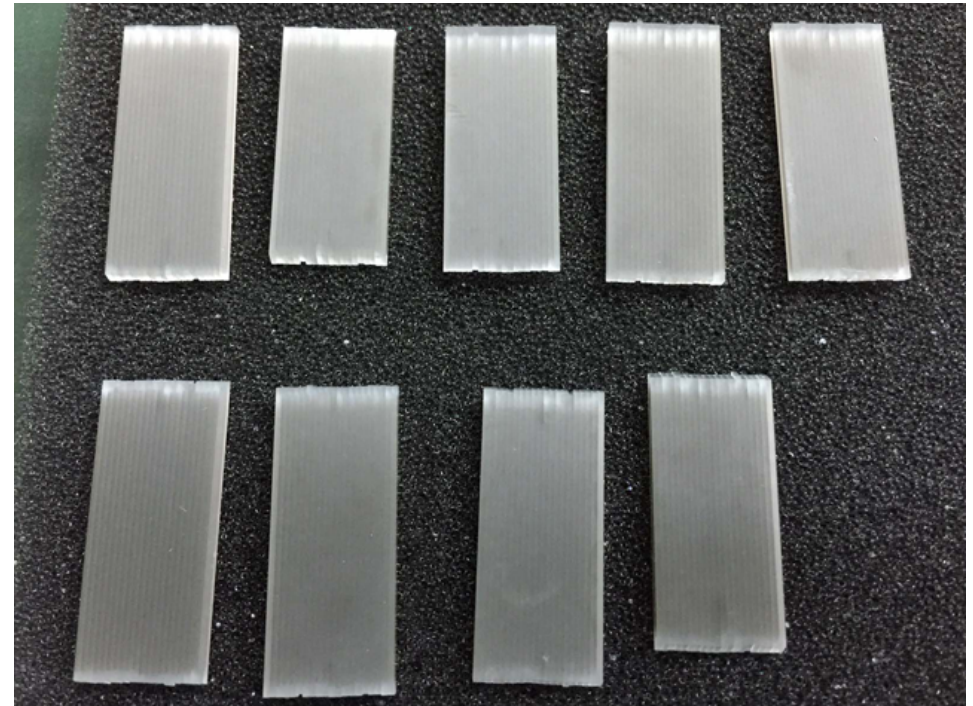


片側あたり Au(20 nm)/Cr(5 nm)の膜厚で Siウエハを接合した際の断面TEM写真

Trial Fabrication of Quasi-Bragg Grating 2



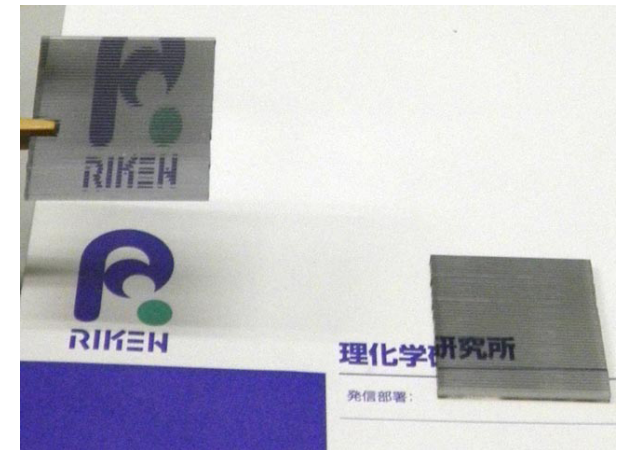
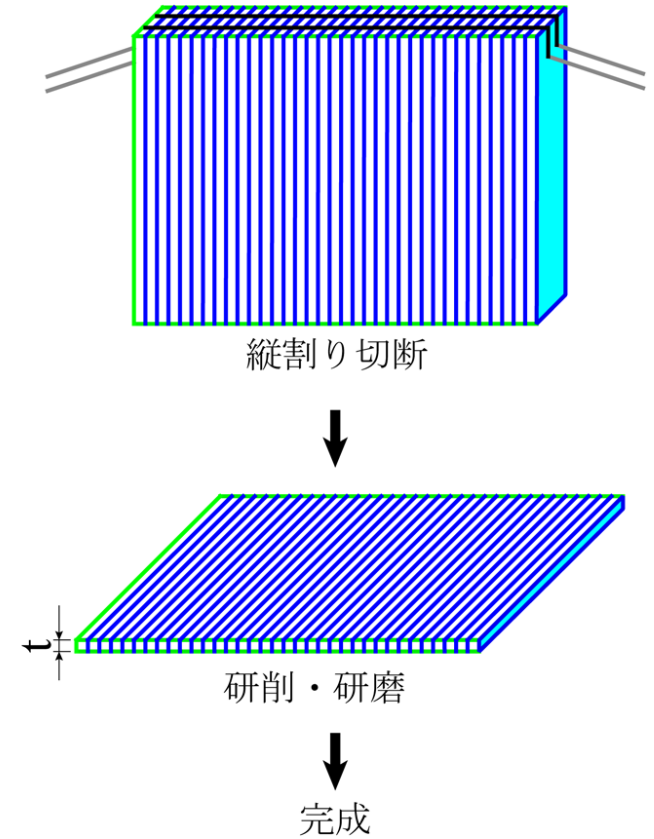
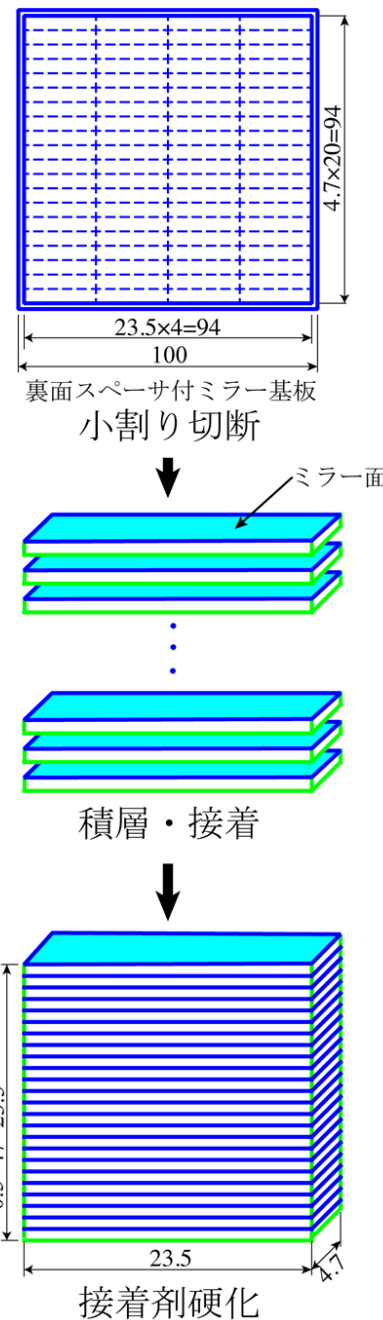
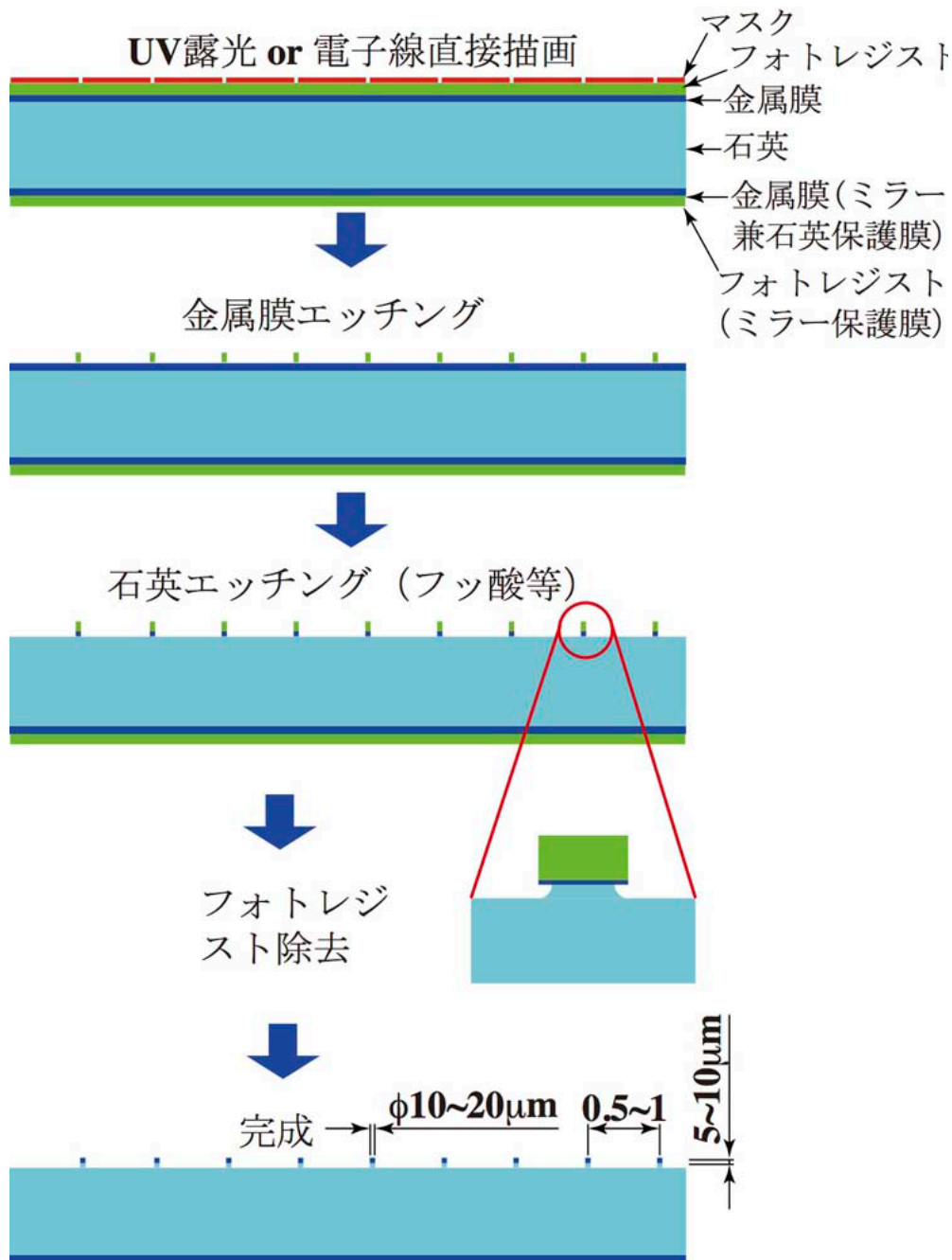
Laminated by gold fusion
in room temperature



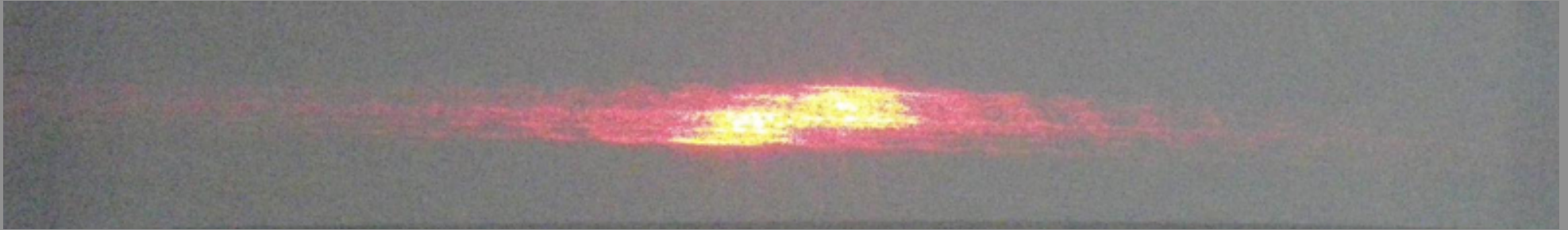
Wire saw cutting.

- 20 sheets of quartz glass substrates of $\phi 25 \times t 0.5$, that the gold deposited by sputtering on both sides, are stacked by a room-temperature bonding (Tohoku University Shimadzu laboratory).
- Thickness to $t 1.1$ by wire saw cutting.
- Thickness to $t 0.9$ by polishing.

Trial Fabrication of Quasi-Bragg Grating 3



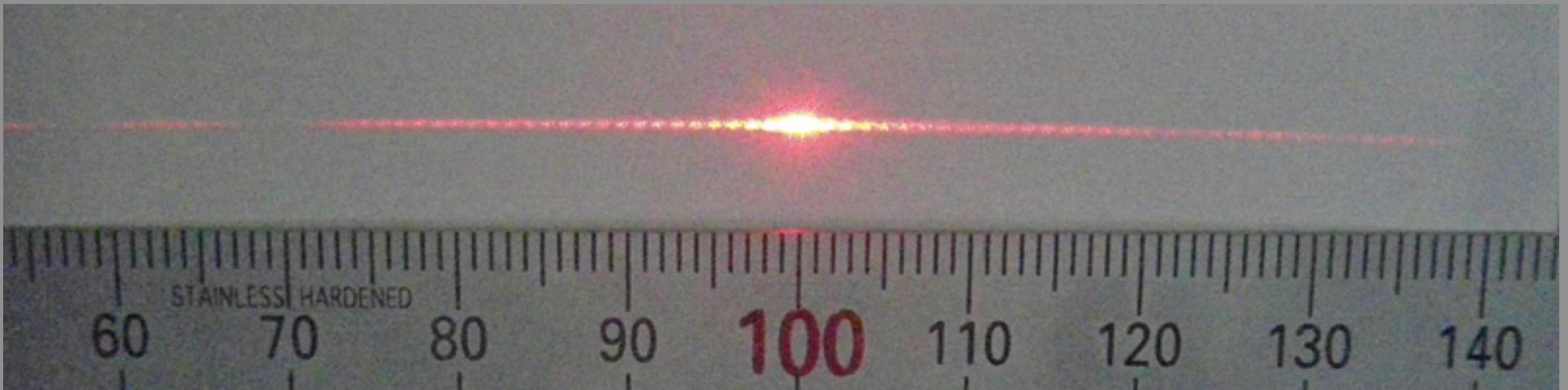
Diffraction Images of Quasi-Bragg Gratings



Laminated by adhesive with glass beads (Trial fabrication 1)

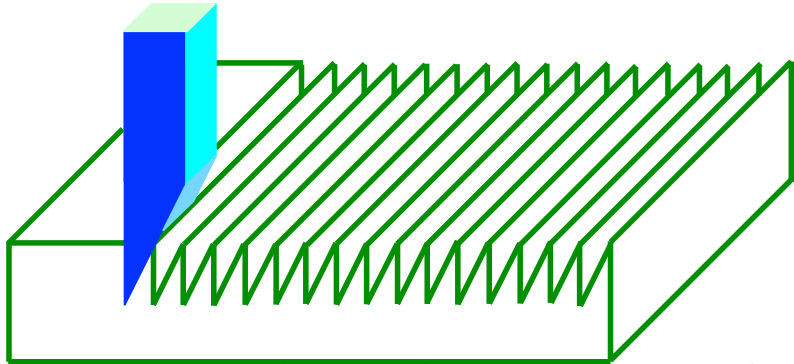


Laminated by gold fusion in room temperature (Trial fabrication 2)

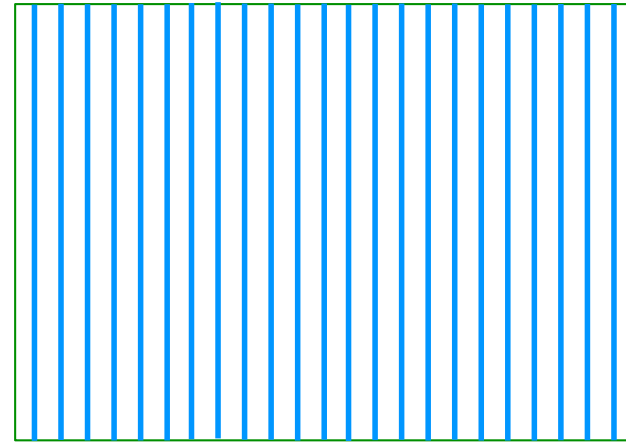


Embossed mirror substrates laminated by adhesive (Trial fabrication 3)

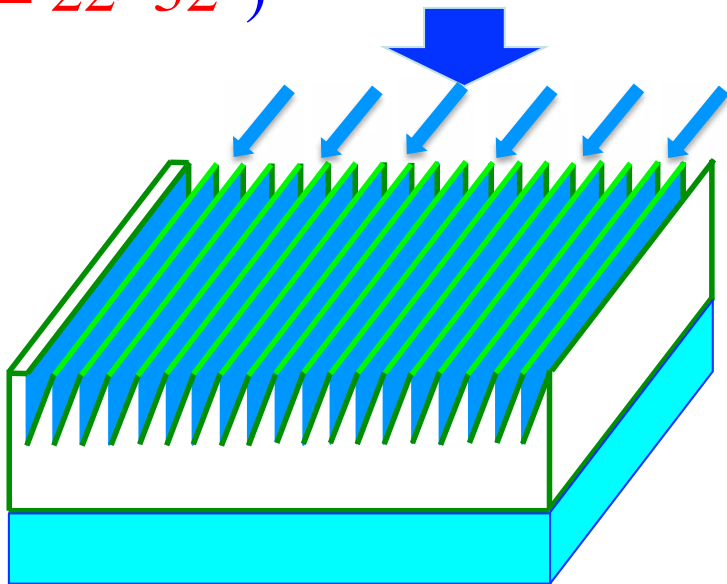
Fabrication Method of Quasi-Bragg Grating



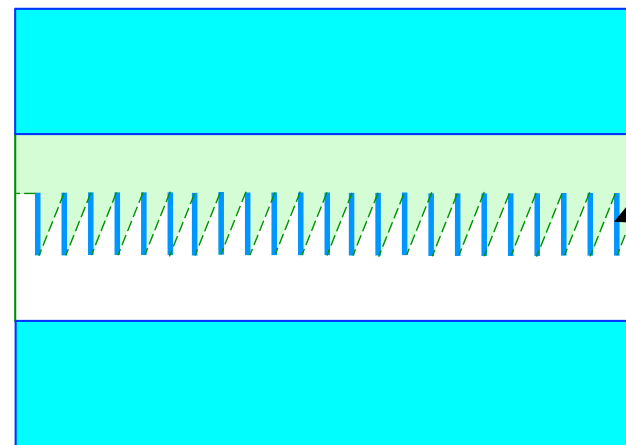
Shaper cutting of master grating
(work: Ni-P alloy of non-
electrolytic plating, $\Lambda = 2 \sim 5 \mu\text{m}$,
 $\gamma = 22 \sim 32^\circ$)



Top view



Oblique ion assisted sputtering of
metallic mirror (Al, $t \sim 100\text{nm}$).



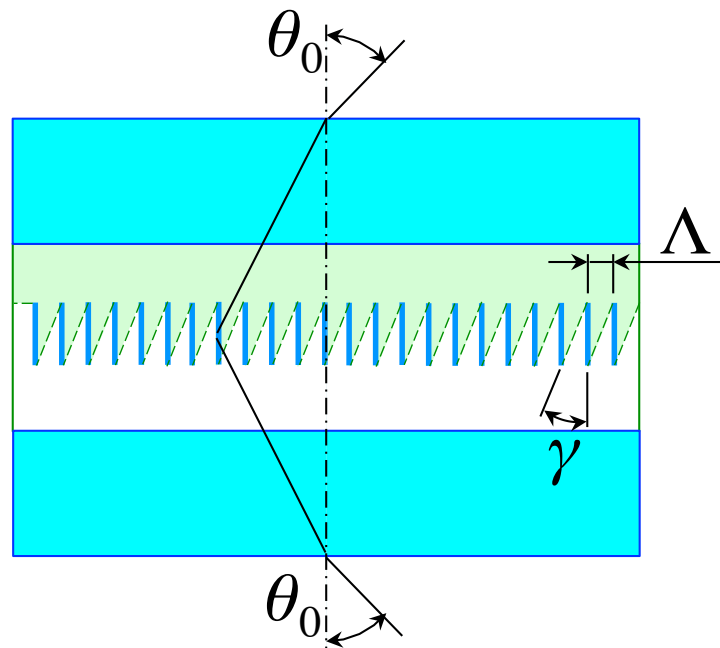
Upper substrate
Clear resin
Metallic mirror
Replicated grating
Lower substrate

Front view

Filling of clear resin into grooves \rightarrow Finish

Quasi-Bragg grating for TMT WFOS

| Item | Λ [μm] ([g/mm]) | θ_0 | γ | Order |
|---------------------|--------------------------------------|------------|--------------|----------|
| Medium Res. Blue #1 | 2.17 (460) | 36° | 22.4° | 5th~8th |
| Medium Res. Blue #2 | 2.70 (370) | 38° | 25.8° | 7th~11th |
| Medium Res. Red | 3.64 (275) | 42° | 23.6° | 5th~9th |
| High Res. Blue | 2.60 (385) | 53° | 31.2° | 8th~13th |
| High Res. Red | 4.65 (215) | 53° | 31.2° | 8th~13th |

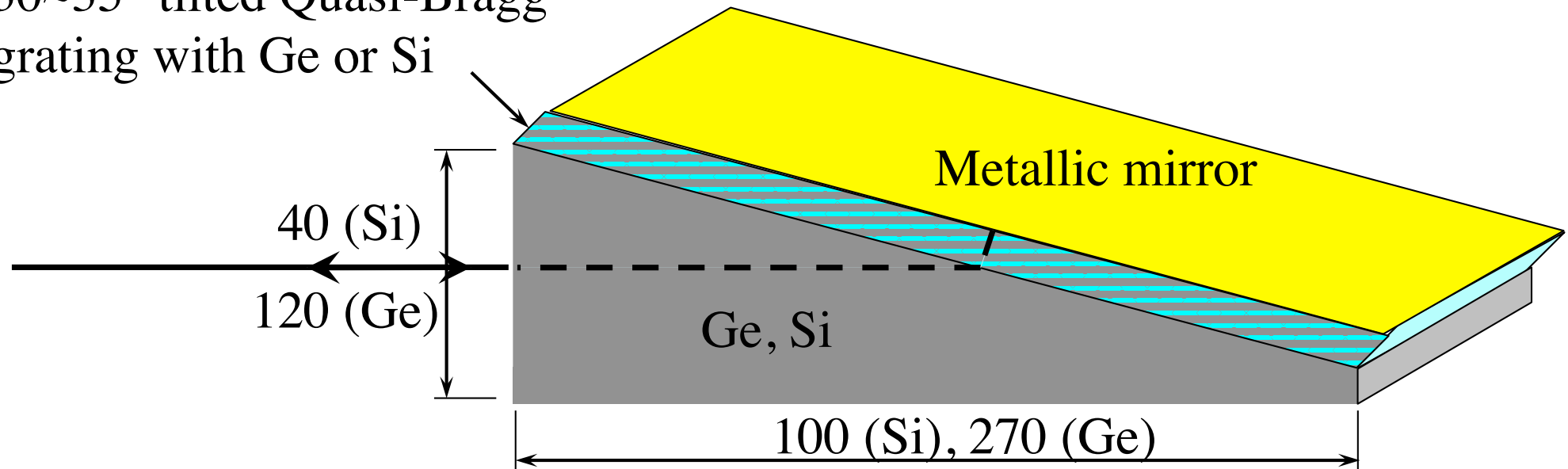


Conclusions

- **VPH grating** achieves high diffraction efficiency and versatile for moderate angular dispersion for the 1st diffraction order.
- Test fabrication of **VPH gratings with liquid crystal of UV curable** is done by using a two beams interferometer of an UV laser.
- Surface relief grating with **acute angle grooves** for **MOIRCS grisms** are going to fabricate.
- **Quasi-Bragg grating** which mirror plates laminated by gold fusion in room temperature (Tohoku University) and embossed mirror substrates laminated by adhesive, are feasible even for echelle spectroscopy of visible wavelength.

Quasi-Bragg Immersion Grating

30~35° tilted Quasi-Bragg grating with Ge or Si



1. Near IR
(1.0~2.5 μm)

Material : ZnSe, Si etc.

Size \times Layers: 40 \times 0.5 \times t0.25 \times 300psc.

Periodic error: 45nm (P-V), 9nm (rms)

2. Mid IR
(5~30 μm)

Material : Ge, CdTe etc.

Size \times Layers: 120 \times 2.0 \times t1.0 \times 300psc.

Periodic error: 150nm (P-V), 30nm (rms)